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(54) LIQUID CRYSTAL DISPLAY DEVICE AND
METHOD OF MANUFACTURING THE SAME

Publication Classification

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(57) **ABSTRACT**

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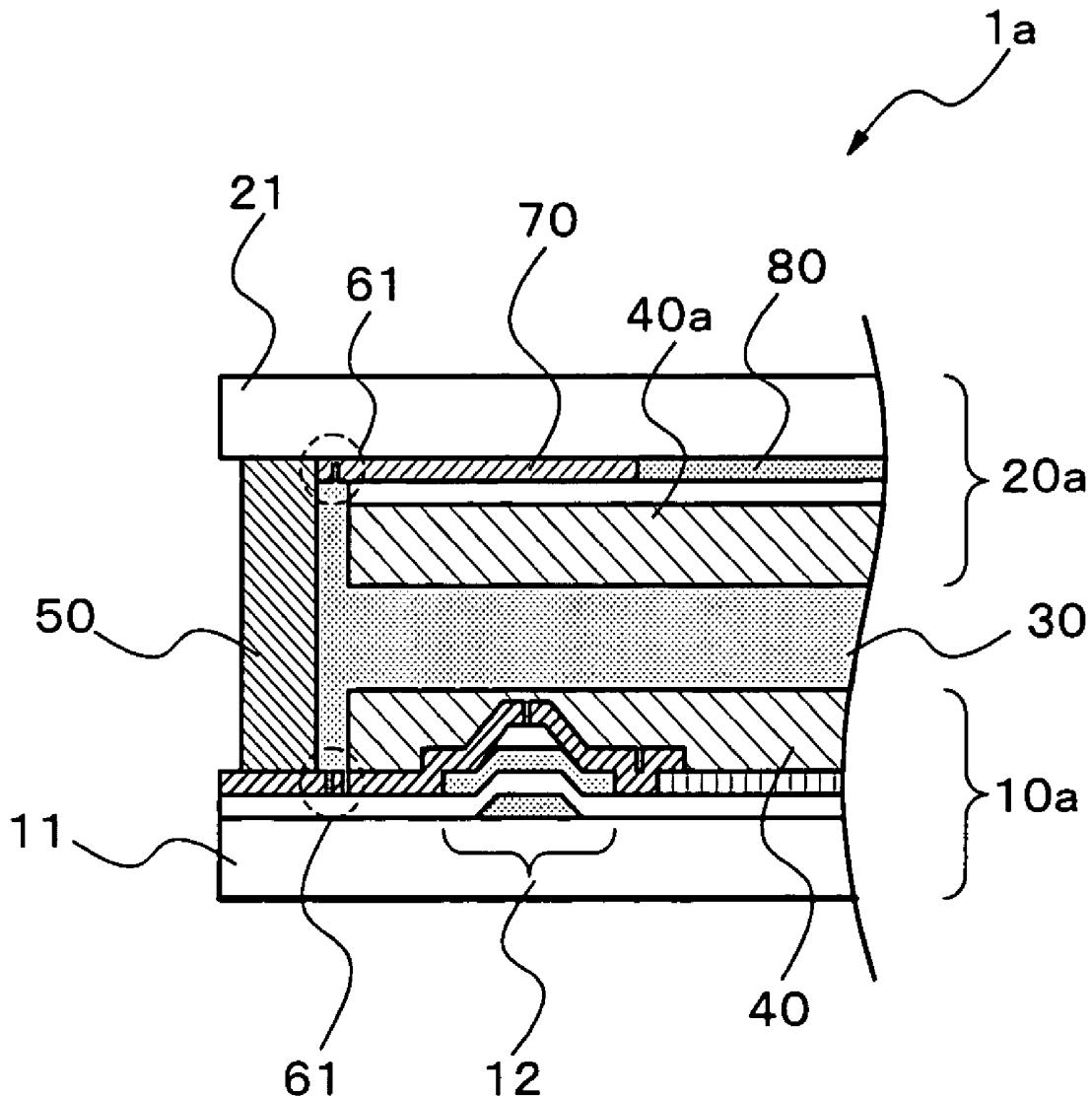
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(30) **Foreign Application Priority Data**

Oct. 21, 2005 (JP) 2005-307468

Provided is a method of manufacturing an LCD device in which alignment films are formed by a method of printing non-contact alignment films on substrates. Print control patterns are provided between a sealing member and each of display regions. Each of the print control patterns is formed of a highly water-repellent region as well as any one of fine concave structures, fine convex structures and pillar-shaped bodies. The print control patterns control the spreading as liquid of alignment film materials to make the film thickness of each of the alignment film materials uniform.



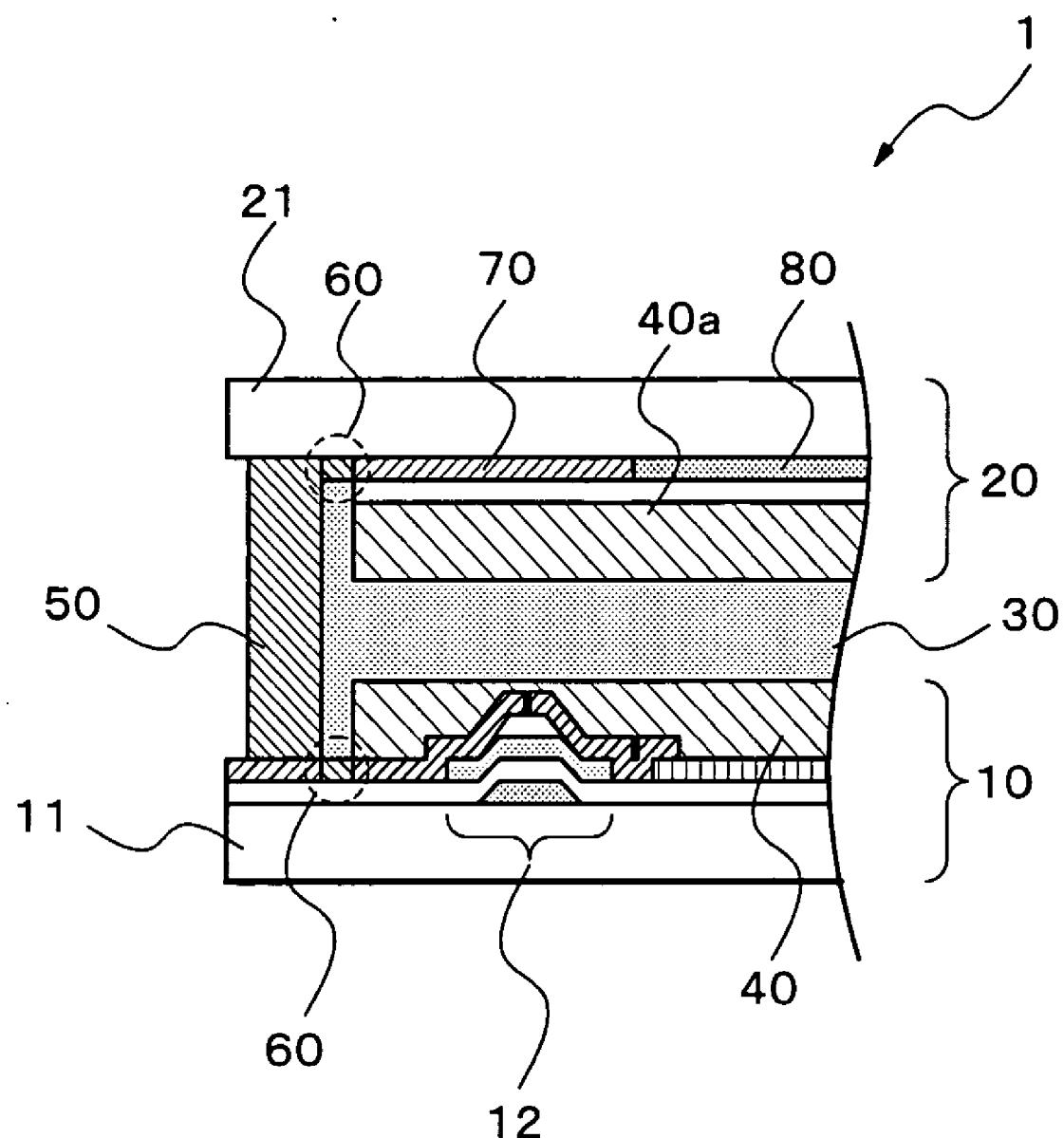


FIG. 1

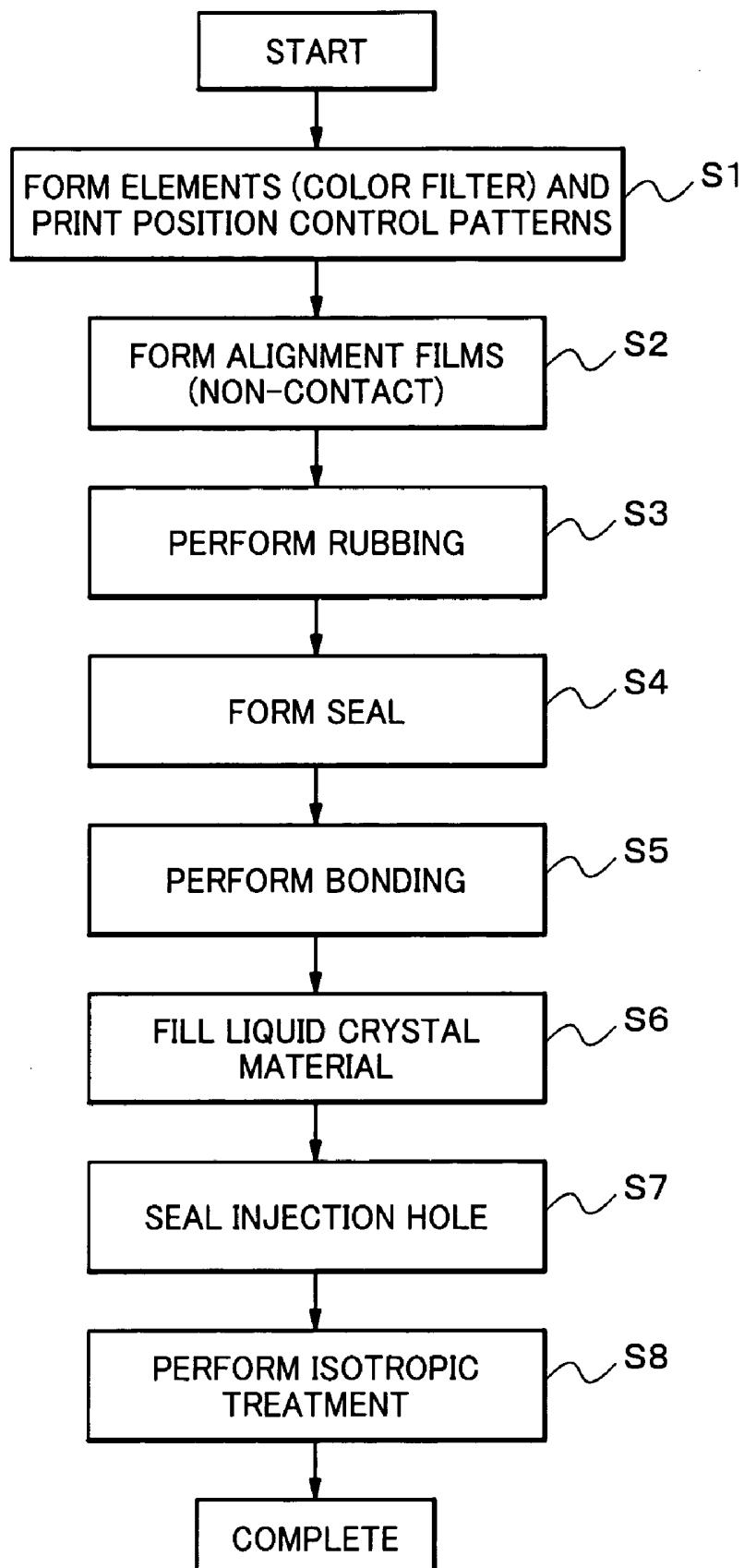
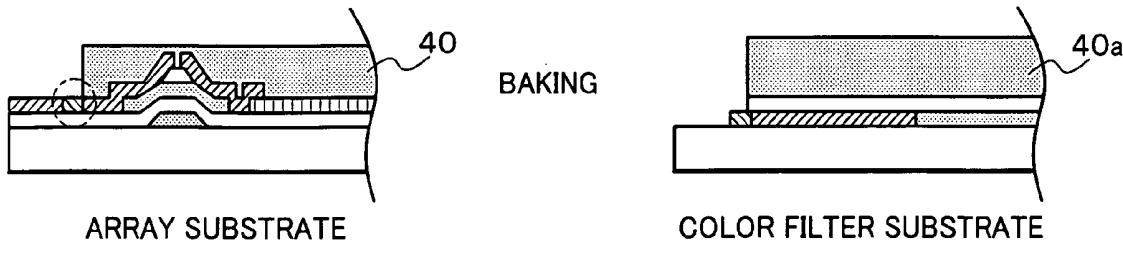
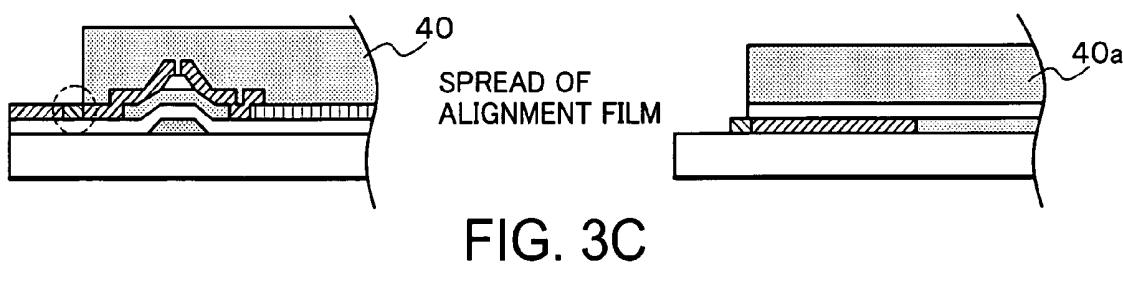
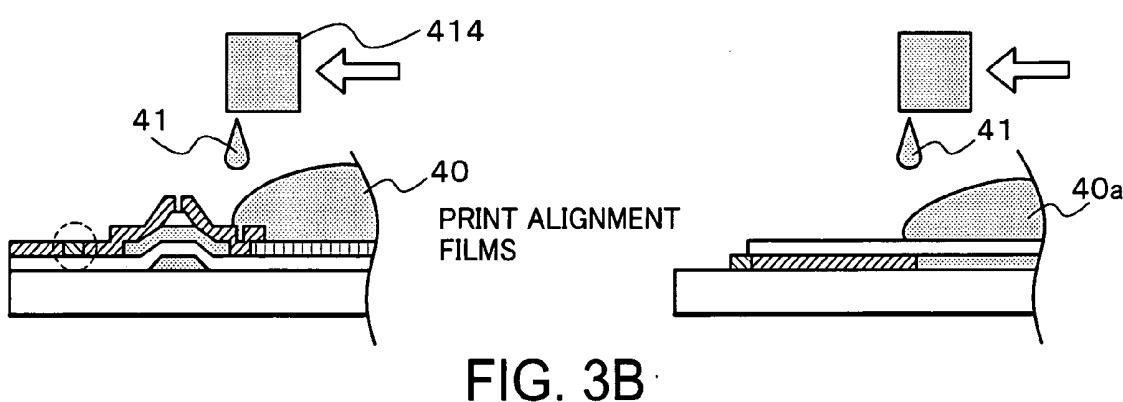


FIG. 2



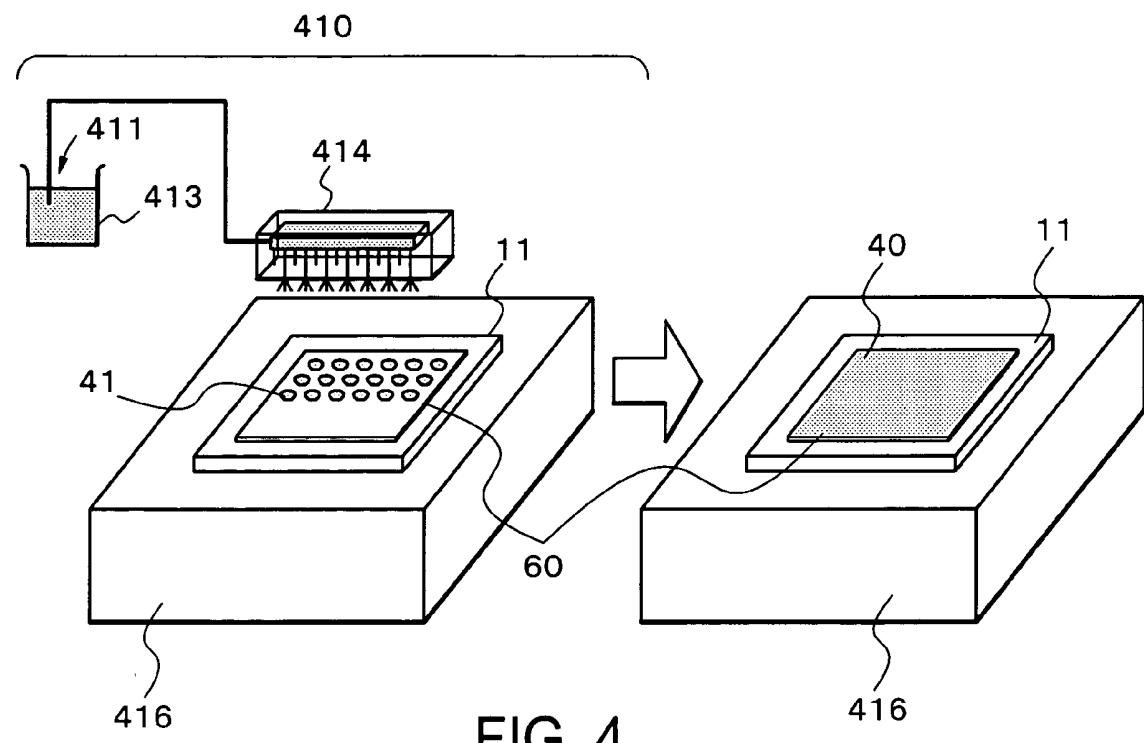


FIG. 4

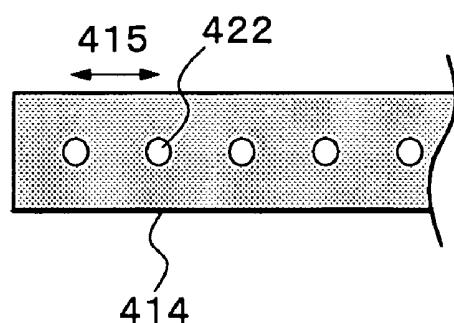


FIG. 5A

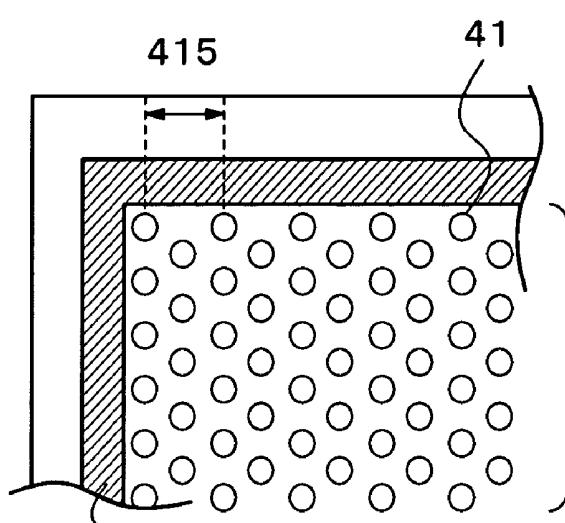


FIG. 5B

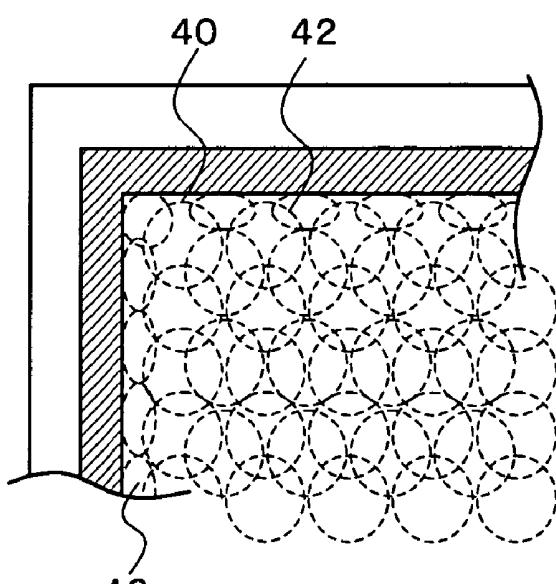


FIG. 5C

FIG. 6A

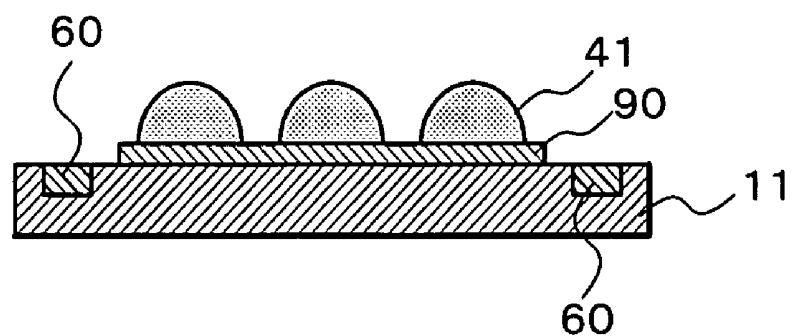


FIG. 6B

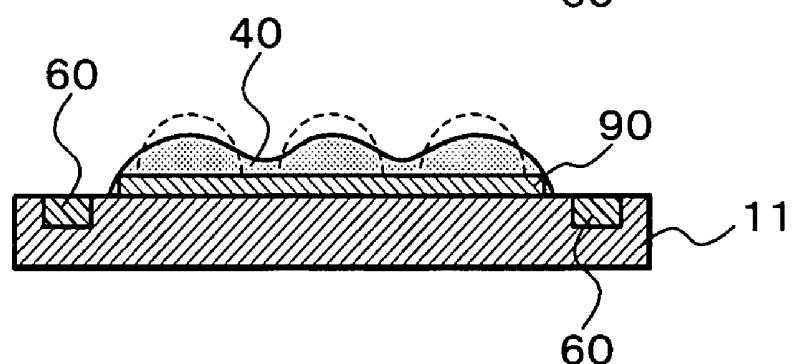


FIG. 6C

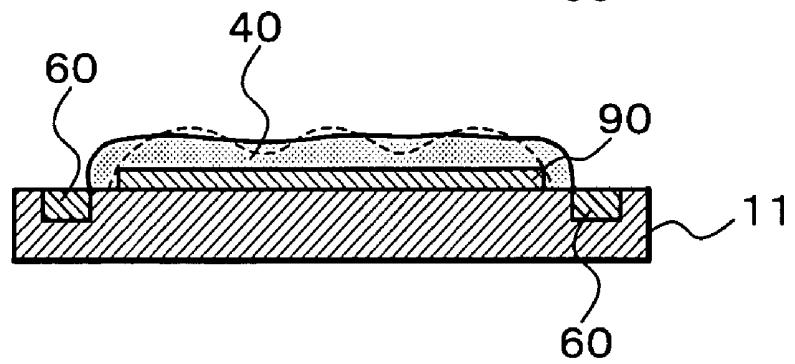
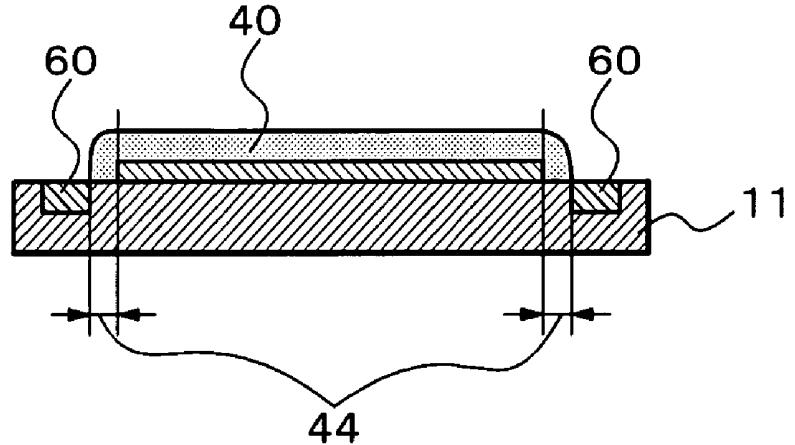


FIG. 6D



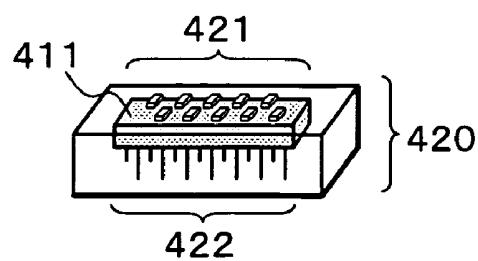


FIG. 7A

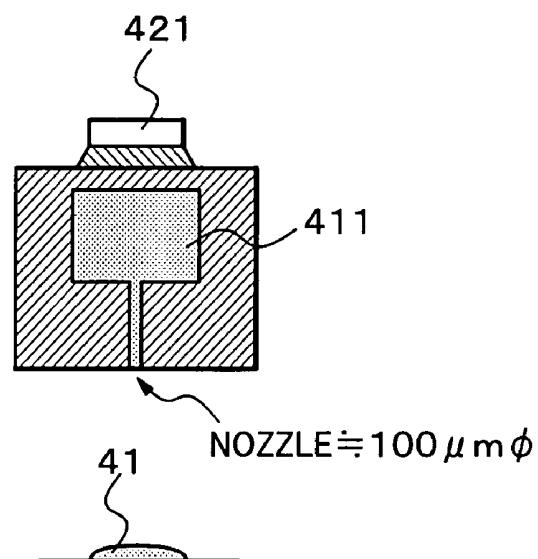


FIG. 7B

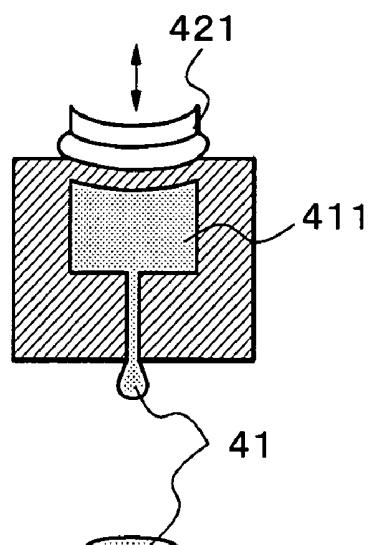


FIG. 7C

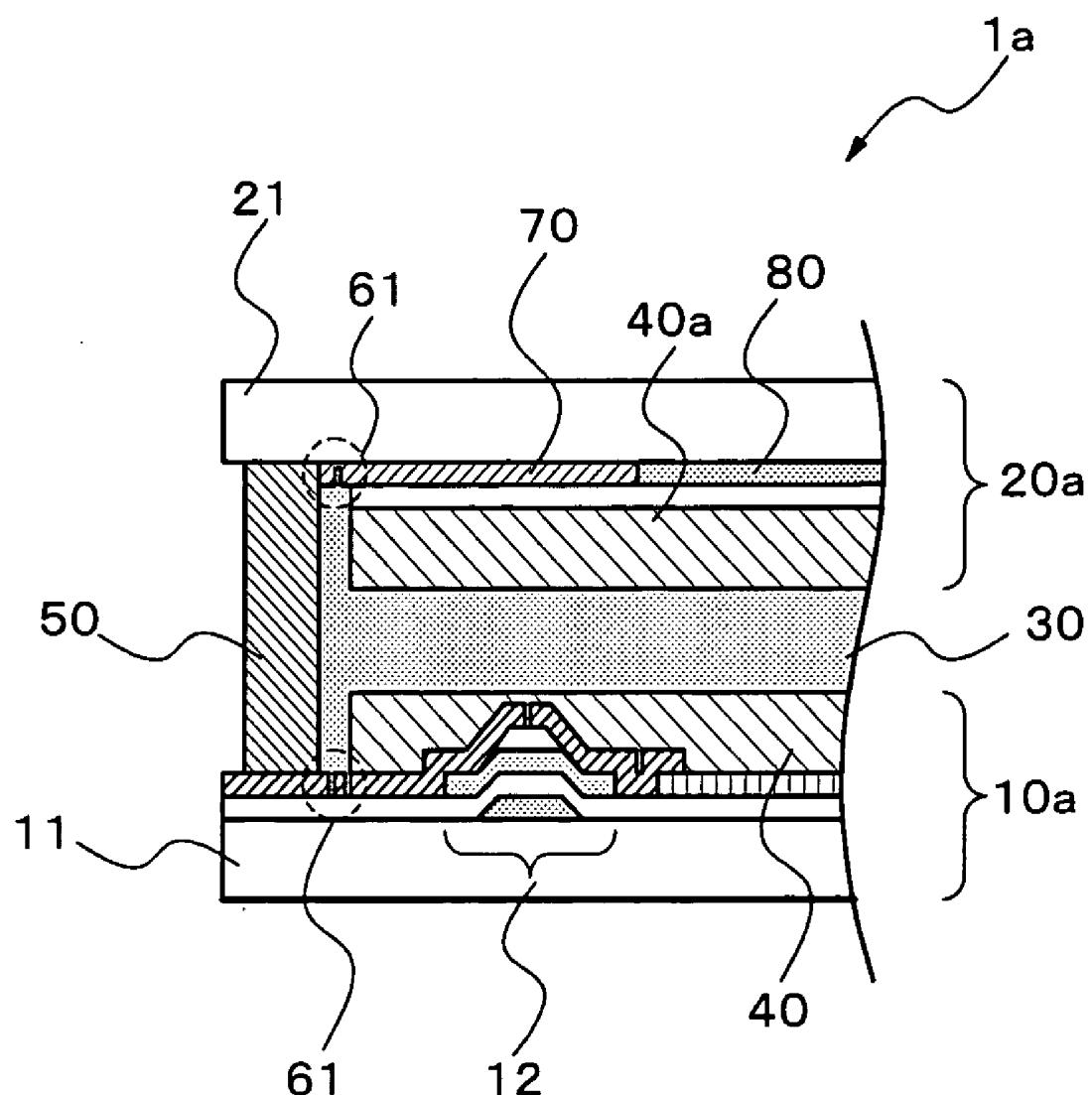
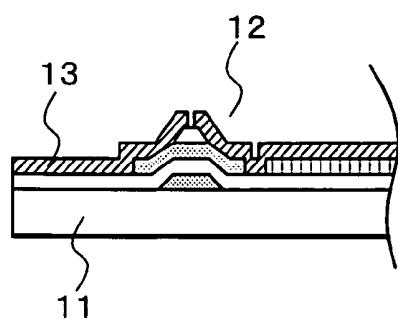


FIG. 8



DEPOSITION

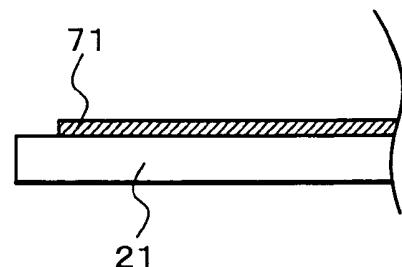
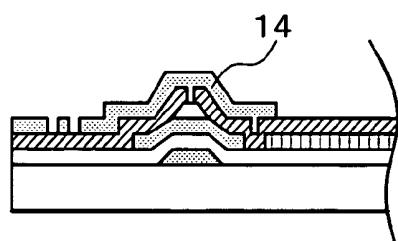


FIG. 9A



EXPOSURE

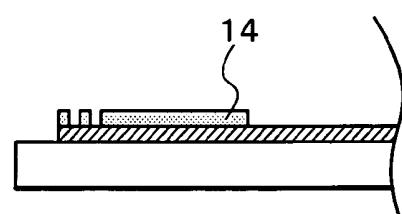
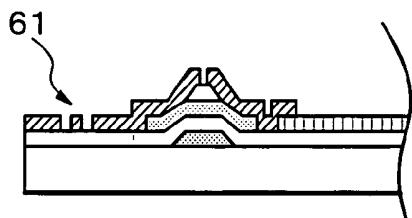


FIG. 9B



ETCHING

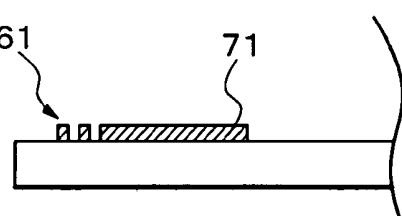
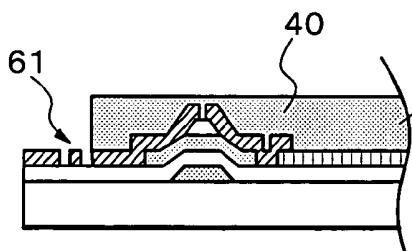
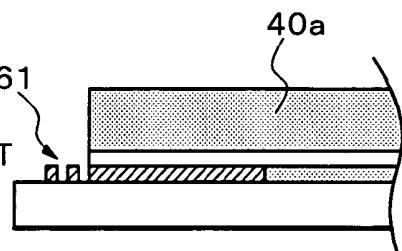


FIG. 9C



PRINT ALIGNMENT FILMS



ARRAY SUBSTRATE

COLOR FILTER SUBSTRATE

FIG. 9D

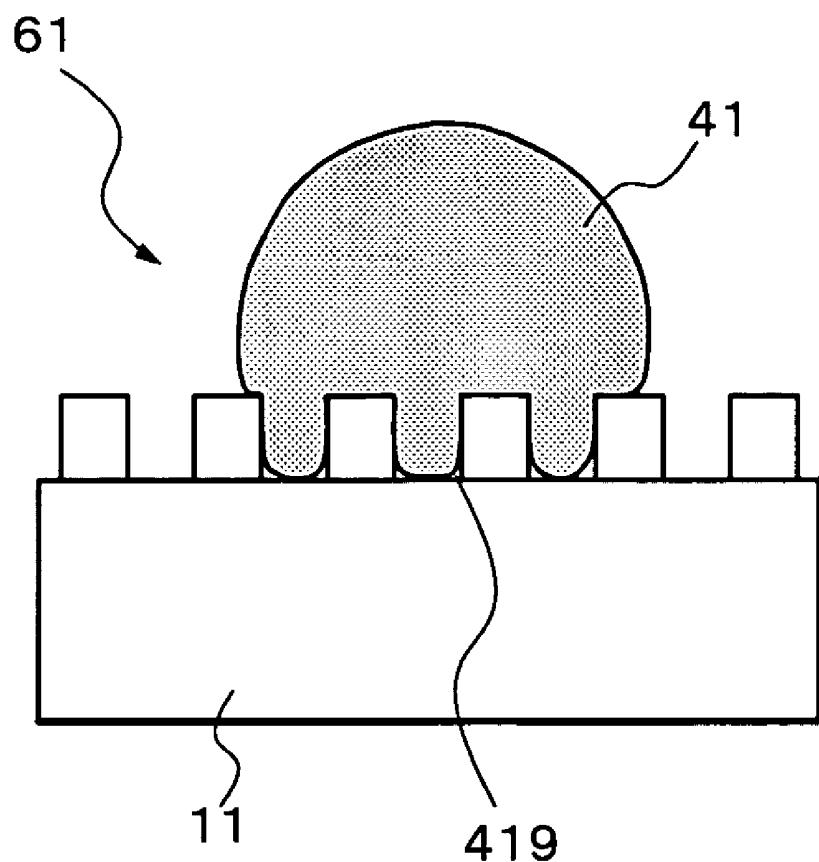


FIG. 10A

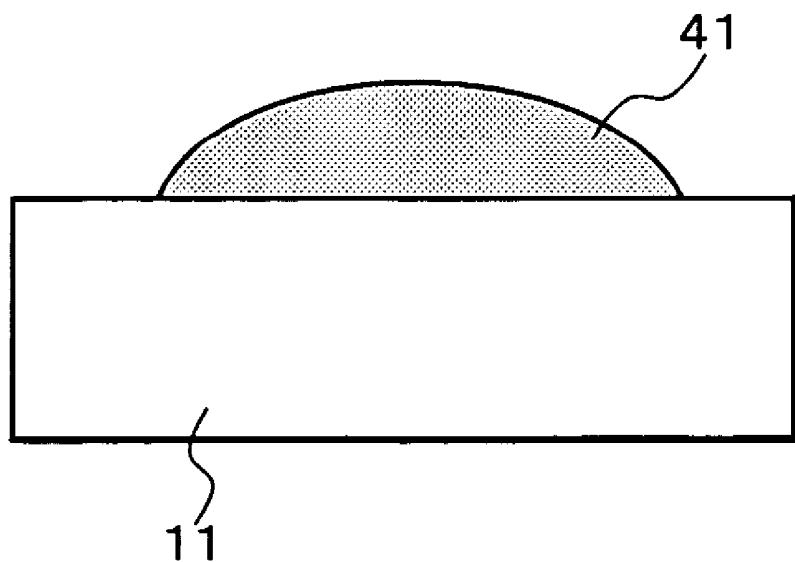


FIG. 10B

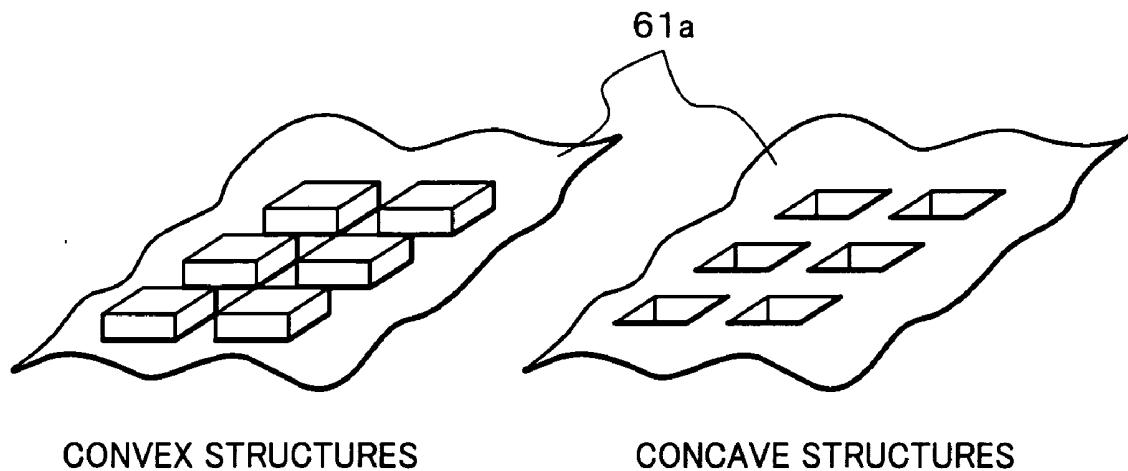


FIG. 11A

FIG. 11B

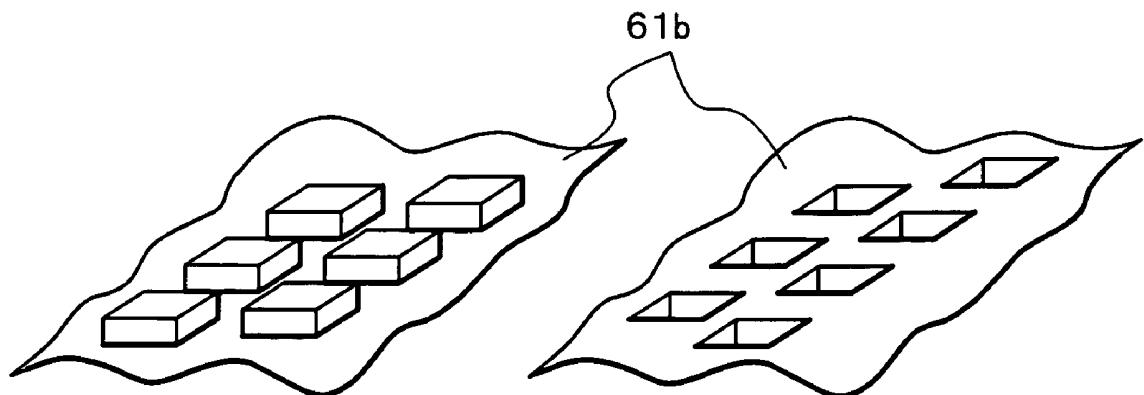


FIG. 12A

FIG. 12B

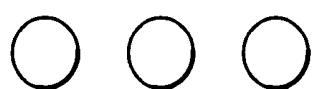
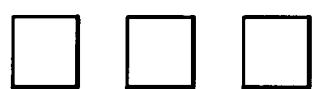
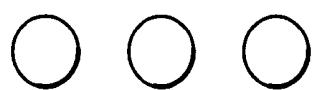
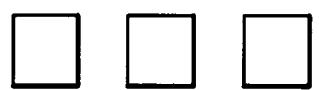
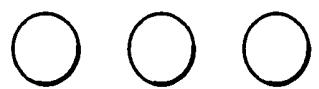
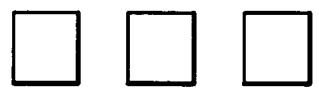


FIG. 13A

FIG. 13B

FIG. 13C

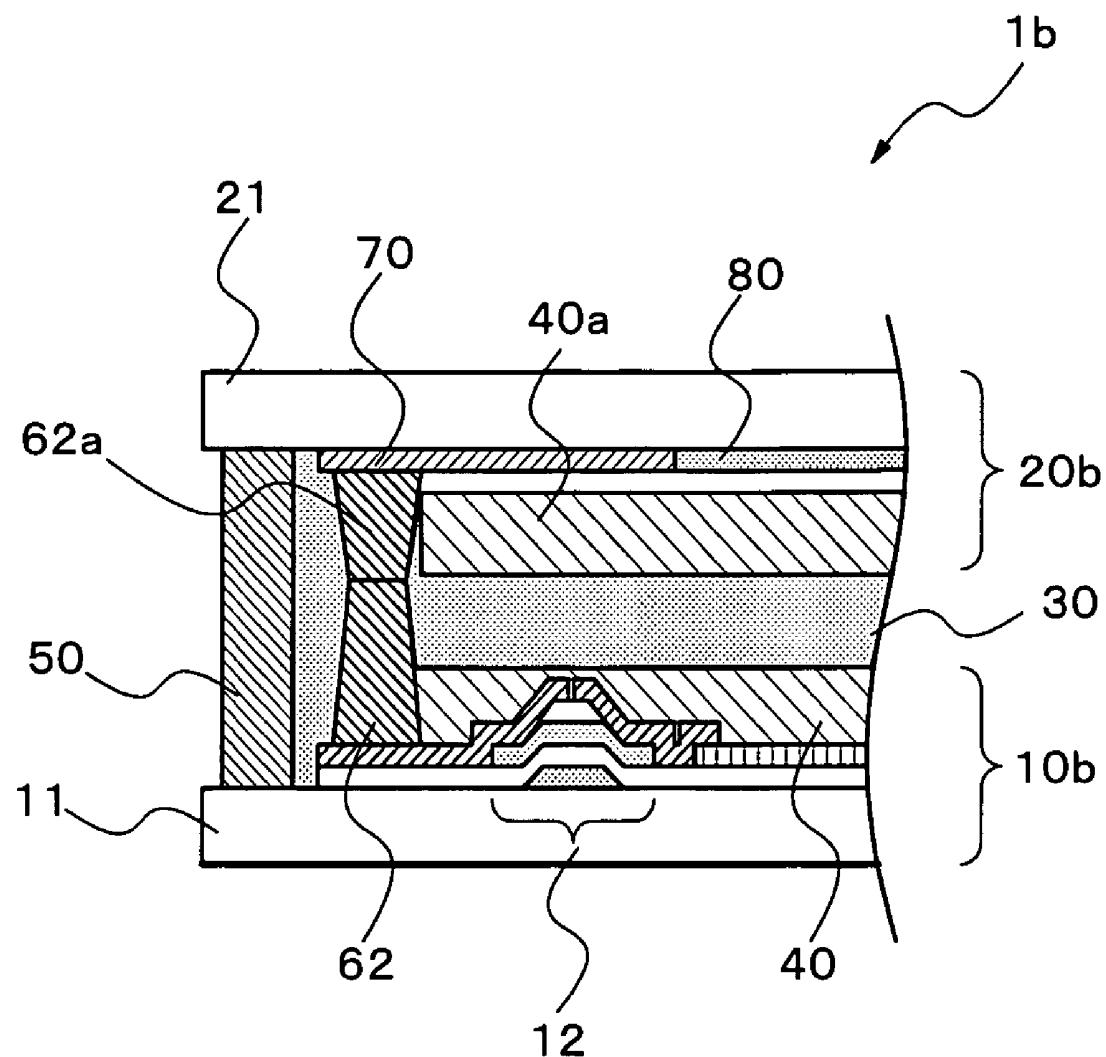


FIG. 14

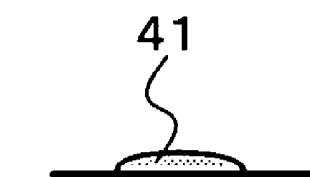
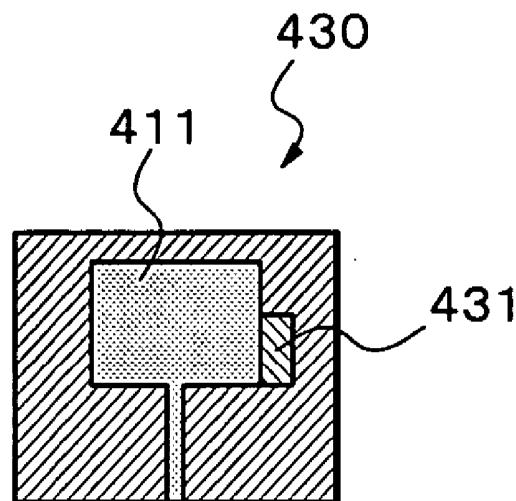


FIG. 15A

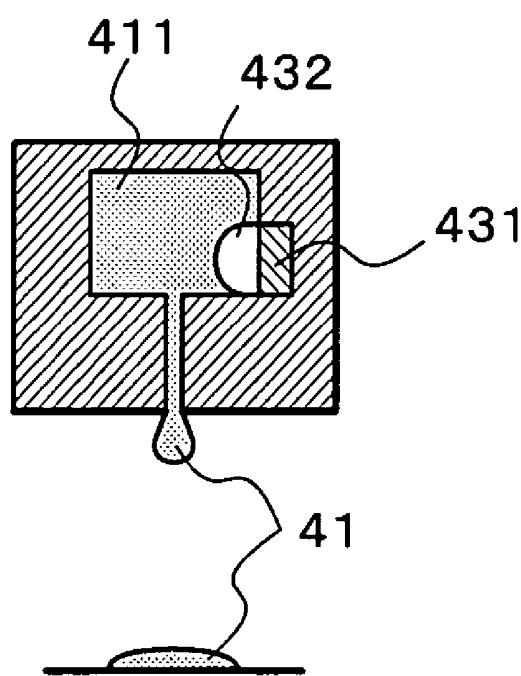


FIG. 15B

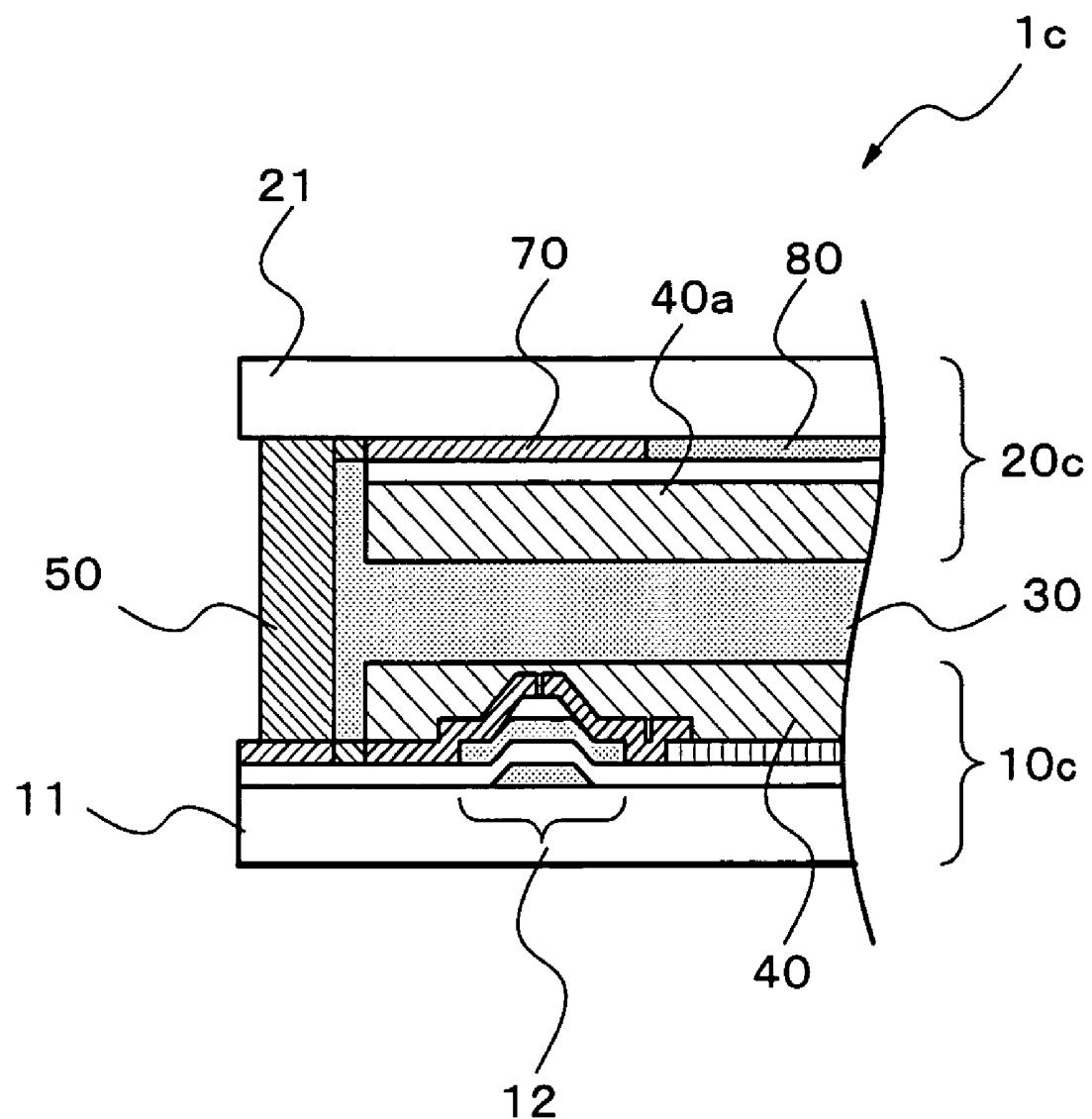
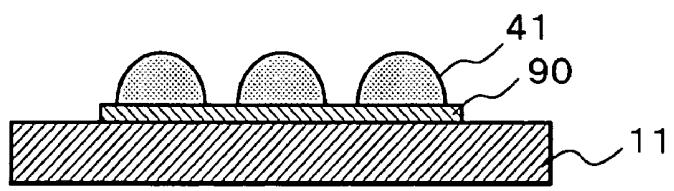
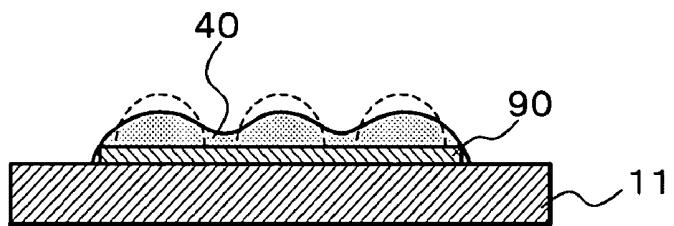


FIG. 16 (PRIOR ART)

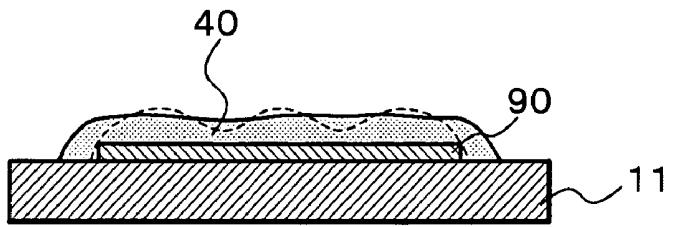
**FIG. 17A
(PRIOR ART)**



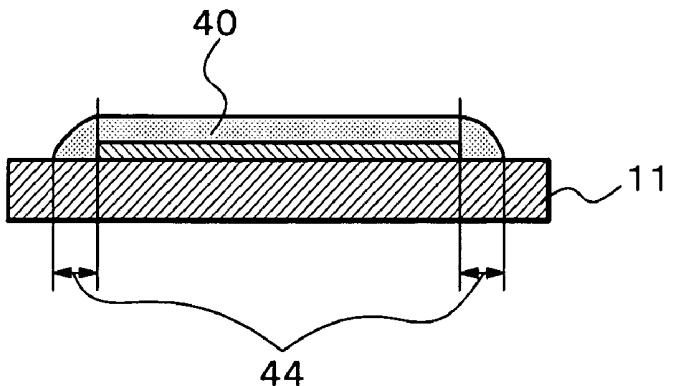
**FIG. 17B
(PRIOR ART)**



**FIG. 17C
(PRIOR ART)**



**FIG. 17D
(PRIOR ART)**



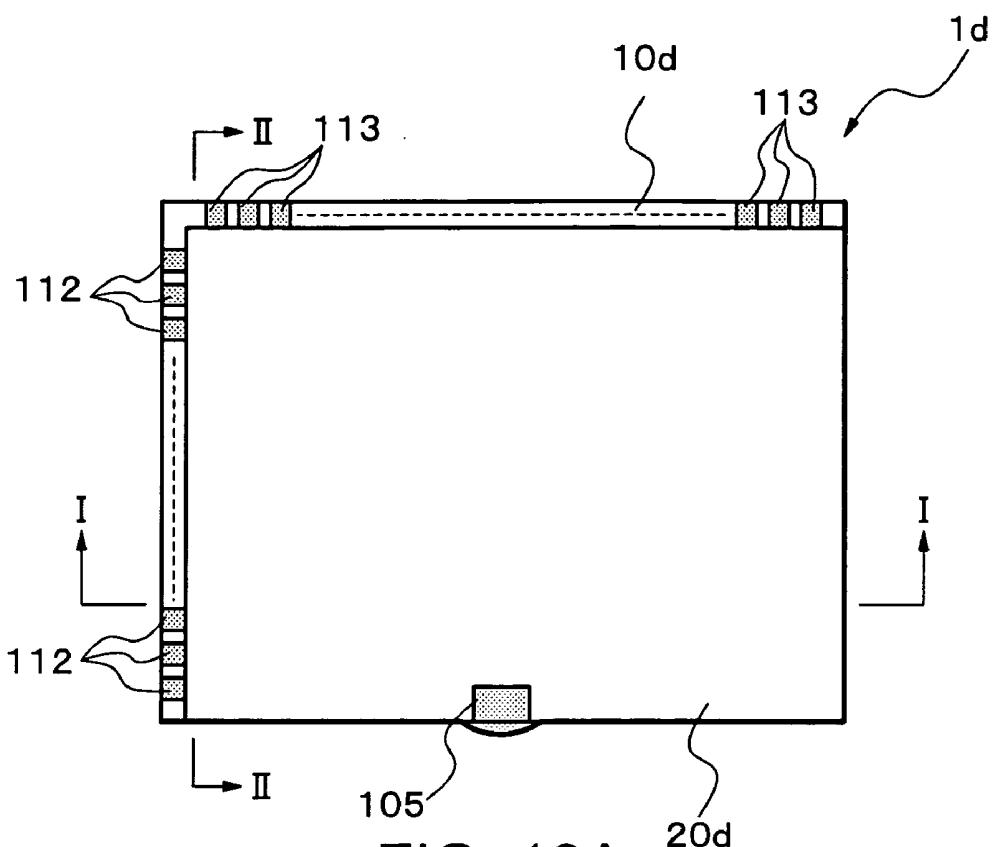


FIG. 18A
(PRIOR ART)

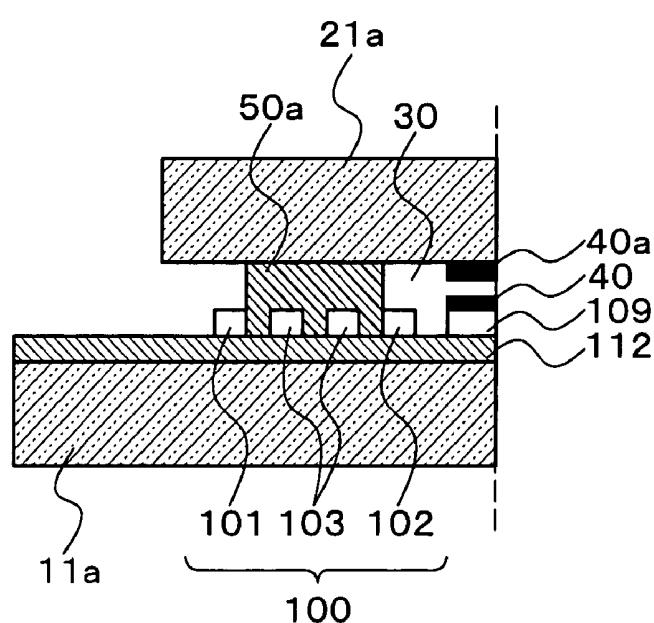


FIG. 18B
(PRIOR ART)

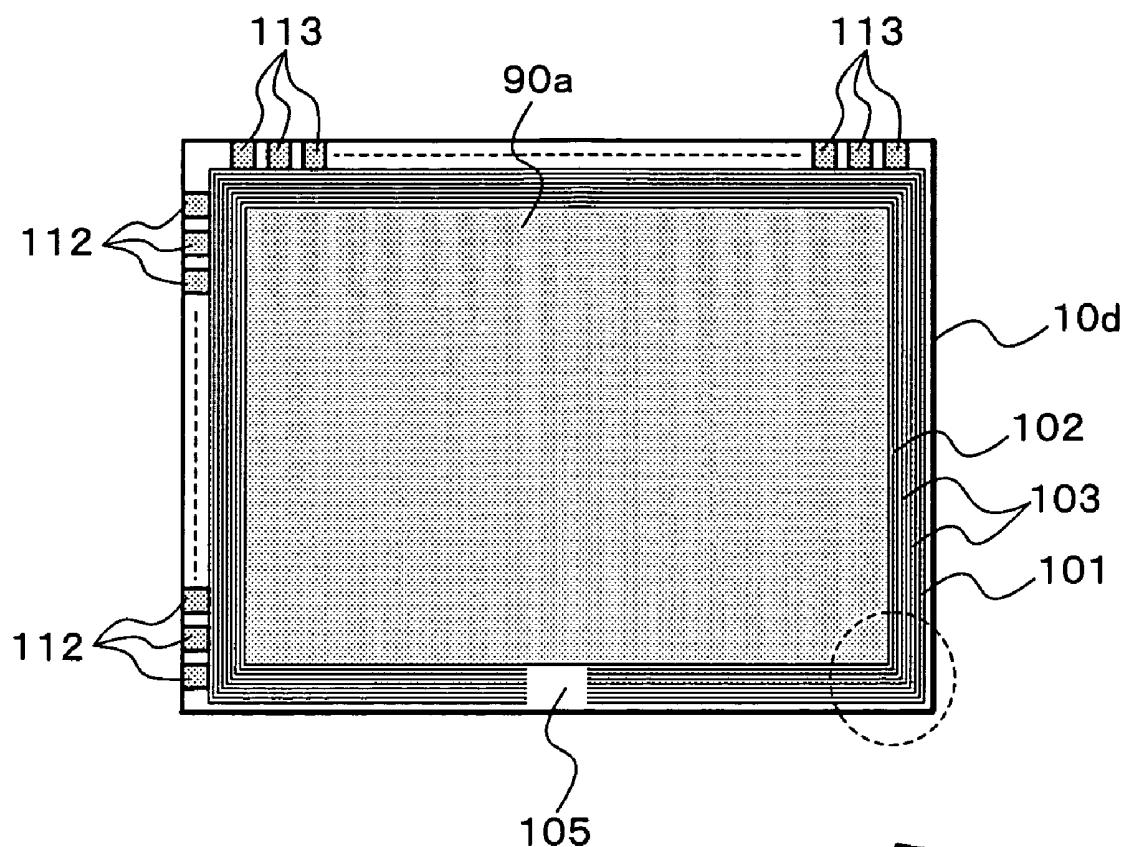


FIG. 19A
(PRIOR ART)

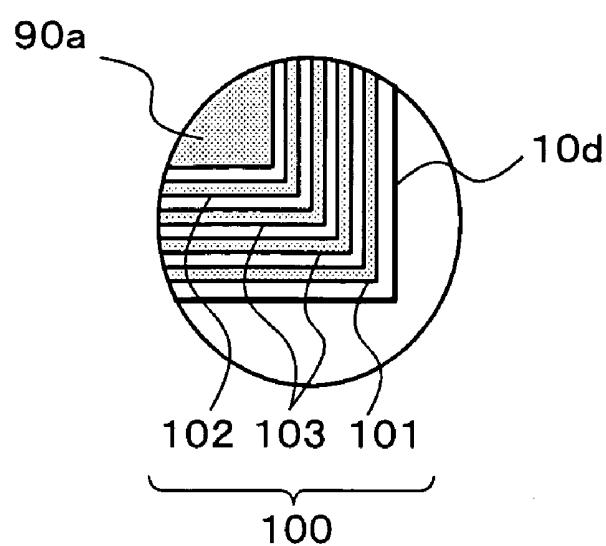
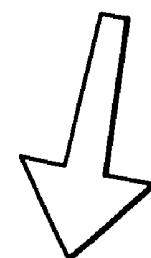


FIG. 19B
(PRIOR ART)

LIQUID CRYSTAL DISPLAY DEVICE AND METHOD OF MANUFACTURING THE SAME

BACKGROUND OF THE INVENTION 1. Field of the Invention

[0001] The present invention relates to a liquid crystal display (LCD) device including alignment films formed by a non-contact method, and a method of manufacturing the same. The present invention particularly relates to the LCD device in which accuracy of a film thickness and contour shape of edge portions of the respective alignment films is improved, and a method of manufacturing the same. 2. Description of the Related Art

[0002] Generally, in an LCD device, a liquid crystal layer is interposed between a substrate including switching elements and another substrate opposite to this substrate, and alignment films are provided to interfaces each between this liquid crystal layer and the substrates. By applying an alignment treatment such as rubbing to the alignment films, liquid crystal molecules in vicinities of the substrates can be respectively aligned in single directions corresponding to the alignment films, the liquid crystal molecules being in the liquid crystal layer.

[0003] As a method of manufacturing the alignment film, a method of manufacturing the same by printing is known. An alignment film printing method of a non-contact type such as an ink-jet method has been proposed for the purpose of such as preventing foreign substances from accreting to the film from a manufacturing device, in a case where the alignment film is printed. In the alignment film printing method of this non-contact type, an alignment film material is discharged as extremely small droplets onto the substrate at equal intervals from a remote position above the substrate. The droplets of the alignment film material, which landed on the substrate, spread as liquid while gradually leveling off by self-weight, thereby an alignment film with a uniform film thickness is expected to be formed.

[0004] However, in practice, the droplets of the alignment film material, which landed on the outermost periphery of a printed region, spread as liquid also in the direction toward the periphery of the printed region, therefore the film thickness is unlikely to be uniform in the periphery of the printed region. Moreover, since the droplets of the alignment film material, which landed on the substrate, tend to spread as liquid along patterns such as wirings, there is a problem that controllability of the film thickness and the contour shape in the printing edge portions is poor.

SUMMARY OF THE INVENTION

[0005] Accordingly, an exemplary feature of the invention is to provide a method of manufacturing an LCD device, the method making it possible to improve patterning accuracy of the edge portions of the respective alignment films when forming the alignment films by a method of printing in non-contact with the substrates. Another exemplary feature of the invention is to provide an LCD device manufactured by such a manufacturing method.

[0006] Moreover, still another exemplary feature of the invention is to provide a method of manufacturing an LCD device, the method making it possible to form alignment films with a highly uniform film thickness when forming the

alignment films in a similar way. Yet another exemplary feature of the invention is to provide an LCD device manufactured by such a manufacturing method.

[0007] A liquid crystal display device of the invention includes: a pair of substrates each including a display region and a peripheral region around the display region; a liquid crystal layer sandwiched between the substrates; a sealing member provided between the peripheral regions of the pair of substrates, the sealing member sealing the liquid crystal layer; alignment films provided between a surface of one of the pair of substrates and the liquid crystal layer, and between a surface of the other of the pair of substrates and the liquid crystal layer; and print position control patterns provided between the sealing member and the display region, the print position control patterns each being made of a member for repelling a corresponding one of alignment film materials which form the alignment films.

[0008] It is preferable that each of the print position control patterns is arranged between the display region and the sealing member.

[0009] It is preferable that the print position control patterns respectively consist of regions each of which can easily repel the alignment film material.

[0010] It is preferable that the regions which can easily repel the corresponding alignment film materials respectively consist of regions with water repellency to the alignment film materials.

[0011] It is preferable that the print position control patterns respectively consist of structures which can easily repel the corresponding alignment film materials.

[0012] It is preferable that the print position control patterns respectively consist of pillar-shaped bodies which are in contact with corresponding opposed substrates, and which support the substrates to keep a cell gap.

[0013] It is preferable that each of the structures which can easily repel the corresponding alignment materials consists of a structure of a pattern repeating at least one of a concave structure and a convex structure.

[0014] It is preferable that a width of each of depression portions of the repeated concave structures or the repeated convex structures of each of the print position control patterns is 50 μm or less.

[0015] It is preferable that an area ratio of the depression portions of the repeated concave structures or the repeated convex structures of each of the print position control patterns to a region of the print position control pattern is $\frac{1}{2}$ or more.

[0016] It is preferable that a depth of each of depressions of the repeated concave structures or the repeated convex structures of each of the print position control patterns is 50 nm or more.

[0017] A method of manufacturing a liquid crystal display device of the invention is a method of manufacturing a liquid crystal display device including a pair of substrates each including a display region and a peripheral region around the display region; a liquid crystal layer sandwiched between the pair of substrates; and a sealing member provided between the peripheral regions of the pair of substrates, the sealing member sealing the liquid crystal layer, the method

including the steps of: forming print position control patterns each made of a member for repelling a corresponding one of alignment film materials which form alignment films, outside the respective display regions of the pair of substrates, forming alignment films respectively on the display regions of the pair of substrates by a non-contact printing method, and bonding the pair of substrates with the sealing member, and interposing the liquid crystal layer between the pair of substrates.

[0018] It is preferable that the print position control patterns are respectively formed of regions each of which can easily repel the alignment film material.

[0019] It is preferable that the regions which can easily repel the corresponding alignment film materials are respectively formed of regions with water repellency which suppresses the spreading of printing the alignment films.

[0020] It is preferable that the print position control patterns are respectively formed of structures which can easily repel the corresponding alignment film materials.

[0021] It is preferable that the structures which can easily repel the corresponding alignment film materials are respectively formed of regions including concave structures or convex structures which suppress the spreading of printing the alignment films.

[0022] It is preferable that a width of each of depression portions of the concave structures or the convex structures of each of the print position control patterns is 50 μm or less.

[0023] It is preferable that an area ratio of the depression portions of the concave structures or the convex structures of each of the print position control patterns to a region of the print position control pattern is $\frac{1}{2}$ or more.

[0024] It is preferable that a depth of each of depressions of the concave structures or the convex structures of each of the print position control patterns is 50 nm or more.

[0025] It is preferable that the regions including the concave structures or convex structures which suppress the spreading of printing the alignment film are formed by a photolithographic method.

[0026] It is preferable that the print position control patterns are formed with a non-contact organic material printing method.

[0027] It is preferable that the print position control patterns are respectively formed of pillar-shaped bodies which enclose the corresponding display regions, and which support the pair of substrates to keep a cell gap.

[0028] It is preferable that the pillar-shaped bodies are formed by depositing color filter layers.

[0029] It is preferable that the non-contact printing method is based on an ink-jet printing method.

[0030] It is preferable that the ink-jet printing method causes droplets of the alignment film material to be discharged by controlling piezoelectric elements.

[0031] It is preferable that the ink-jet printing method causes droplets of the alignment film material to be discharged by controlling heaters.

[0032] It is preferable that the non-contact printing method is based on a dispense printing method.

[0033] According to the method of manufacturing the liquid crystal display device of the invention, there are formed print position control patterns each made of a member for repelling the alignment film material which forms the alignment films, outside the display regions of the pair of substrates. This results in the exemplary advantages as follows.

[0034] According to the invention, when forming alignment films by the non-contact printing method, even if the alignment film material spreads as liquid in the direction toward the periphery of the display regions, the print position control patterns can repel the alignment film material to thereby control the spreading as liquid of the alignment film material. This makes it possible to form alignment films having small variations in the film thickness between the center of the display region and the edge portion of the display region. Because it is possible to control the spreading as liquid of the alignment film material, the patterning of the edge portion of the alignment film is facilitated.

[0035] According to the liquid crystal display device of the invention, between the sealing member and the display region, there are provided print position control patterns each made of a member for repelling the alignment film material which forms the alignment films. This results in the exemplary advantages as follows.

[0036] According to the invention, when forming alignment films by the non-contact printing method, even if the alignment film material spreads as liquid in the direction toward the periphery of the display region, it is possible to control the spreading as liquid of the alignment film material by the print position control patterns which repel the alignment film material. Accordingly, it is possible to obtain the liquid crystal display device in which the film thickness of the alignment films is uniform with no irregularity, and in which the patterning accuracy of the alignment films is excellent. Moreover, as a result that the patterning accuracy of the alignment films has been improved, it is possible to realize the liquid crystal display device which has no display irregularity, to improve the display quality of the liquid crystal display device, and to downsize the liquid crystal display device.

BRIEF DESCRIPTION OF THE DRAWINGS

[0037] These and other objects and advantages and further description of the invention will be more apparent to those skilled in the art by reference to the description, taken in connection with the accompanying drawings, in which:

[0038] FIG. 1 is a cross sectional view showing a partial structure of an LCD device concerning an embodiment of the invention;

[0039] FIG. 2 is a flowchart which shows a part of the process of a method of manufacturing the LCD device of FIG. 1;

[0040] FIGS. 3A to 3D are cross sectional views of an array substrate and a color filter substrate of the LCD device in order of manufacturing steps for explaining an alignment film printing process of a first embodiment of the invention;

[0041] FIG. 4 is a schematic view for explaining the configuration of an alignment film printing apparatus used in the alignment film printing process of FIG. 3;

[0042] FIG. 5A is a perspective view for explaining a print head used in an alignment film dripping process of FIG. 3, and FIGS. 5B and 5C are partial plane views of the LCD device by the dripping of the alignment film of FIG. 3;

[0043] FIGS. 6A to 6D are partial sectional views of the LCD device for explaining a process of the spreading as liquid of the alignment film material of FIG. 3;

[0044] FIG. 7A is a perspective view of the print head of the alignment film printing apparatus concerning FIG. 4, and FIGS. 7B and 7C are cross sectional views for explaining the operation of the print head of FIG. 7A;

[0045] FIG. 8 is a cross sectional view showing a partial structure of an LCD device concerning a second embodiment of the invention;

[0046] FIG. 9A to FIG. 9D are cross sectional views showing the structure of the array substrate and the color filter substrate of the LCD device in order of manufacturing steps for explaining the alignment film printing process of FIG. 8;

[0047] FIGS. 10A and 10B are cross sectional views for explaining the alignment film printing process of FIG. 8;

[0048] FIGS. 11A and 11B are perspective views of an example of a print position control pattern 61 of FIG. 8;

[0049] FIGS. 12A and 12B are perspective views of other examples of the print position control patterns 61 of FIG. 8;

[0050] FIGS. 13A to 13C are plane views of still other examples of the print position control patterns 61 of FIG. 8;

[0051] FIG. 14 is a cross sectional view showing a partial structure of an LCD device concerning a third embodiment of the invention;

[0052] FIGS. 15A and 15B are cross sectional views showing another print head of the alignment film printing apparatus concerning a fourth embodiment of the invention;

[0053] FIG. 16 is a cross sectional view showing a partial structure of an LCD device of a first related art;

[0054] FIGS. 17A to 17D are cross sectional views for explaining the manufacturing process of alignment films in FIG. 16;

[0055] FIG. 18A is a plane view showing a partial structure of an LCD device of a second related art, and FIG. 18B is a partial sectional view taken along the I-I line or the II-II line of FIG. 18A; and

[0056] FIG. 19A is a plane view of an array substrate of FIG. 18, and FIG. 19B is an enlarged partial view of FIG. 19A.

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

[0057] Before describing preferred embodiments, the related arts are described with reference to the accompanying drawings.

[0058] Firstly, a first related art is described. Referring to FIG. 16, an LCD device 1c includes an array substrate 10c as a first substrate, a color filter substrate 20c as a second substrate, a sealing member 50 joining these first and second substrates, and a liquid crystal layer 30 interposed between

the first and second substrates. Alignment films are provided on surfaces of the respective substrates, the surfaces being in contact with the liquid crystal layer 30. The array substrate 10c is provided with, on a substrate 11, thin film transistors (TFTs) 12 as switching elements, and pixel electrodes as well as other electrodes to serve as a display region, the pixel electrodes and the other electrodes being connected to the switching elements. The array substrate 10c is provided with an alignment film 40 on top of the substrate 11 on which these elements are provided. The color filter substrate 20c is provided with a black matrix 70 and a color filter 80 on a substrate 21. The color filter substrate 20c is provided with an alignment film 40a on the black matrix 70 and the color filter 80. Moreover, the alignment films 40 and 40a are deposited by discharging the alignment material from above the respective substrates by the non-contact printing method and by baking them.

[0059] In the first related art, the alignment films 40 and 40a are formed as shown in the cross sectional views in order of the steps of FIGS. 17A to 17D. First, as shown in FIG. 17A, droplets 41 of an alignment film material are discharged to a display region 90 on the substrate 11. The droplets 41 of this alignment film material spread as liquid in the direction toward the periphery of the display region 90 while leveling off by self-weight gradually, as shown in FIGS. 17B and 17C. Then, as shown in FIG. 17D, the flat alignment film 40 is formed. However, in this case, the edge portion of the alignment film 40 results in a region 44 whose film thickness is small. Accordingly, there is a problem that the film thickness of the alignment film 40 is unlikely to be uniform.

[0060] Moreover, when the alignment film material is printed onto a long and narrow groove such as wirings, the printed alignment film material spreads as liquid along the groove. Therefore this causes a problem such as an uneven film thickness or wide variations of the spreading as liquid of the alignment film material at the edge portions of the respective alignment films. For this reason, it is extremely difficult to control the film thickness and the contour of the edge portions of the respective alignment films in the periphery of the display region in which wiring patterns are formed. If the alignment film extends in the direction toward the periphery of the panel along wirings at the alignment film edge, a part of the alignment film is formed under a sealing position. This decreases the reliability of the LCD device. In order to solve the above problems, the space between the display region and the seal needs to be widened, however this results in a wide bezel area of the LCD device.

[0061] Moreover, in the case of the alignment film formed by the alignment film printing method of the non-contact type, there is a problem that it is difficult to control uniformity of the film thickness. Because a resin such as a varnish printed onto the substrate spreads by self-weight, the resin is thick in the center of the print region and is slightly thin in the periphery. For this reason, the film thickness of the alignment film after evaporating solvent by the temporarily drying becomes large in the center and small in the periphery. In a case where the LCD device is assembled using the alignment films having variations in the film thickness, the alignment of the liquid crystal within a plane becomes uneven. Therefore this leads to a decrease in the display quality and reliability.

[0062] Next, a second related art is described. As the second related art, there is an LCD device proposed in Japanese Patent Application Laid-Open. No. 2001-330837. As shown in FIGS. 18A and 18B, this LCD device 1d is configured by bonding an array substrate 10d and a color filter substrate 20d to each other with a sealing member 50a interposed in between, and by filling a liquid crystal material between the array substrate 10d and the color filter substrate 20d to provide a liquid crystal layer 30. On the array substrate 10d, a plurality of gate lines 112 and a plurality of drain lines 113 are arranged in a matrix. Pixel electrodes, the gate lines 112 and the drain lines 113 are connected via switching elements (not shown) which are arranged at each intersection of the gate lines 112 and the drain lines 113, and thereby a display region is configured.

[0063] Moreover, gate line driving circuits (not shown) and drain line driving circuits (not shown) are respectively connected to the gate lines 112 and the drain lines 113. Moreover, an alignment film 40 is formed on the pixel electrodes, the switching elements, the gate lines 112 and the drain lines 113, which are formed in this manner.

[0064] Moreover, as shown in FIG. 19B, several concavo-convex patterns 100 are formed in the peripheral region of the array substrate 10d. These concavo-convex patterns 100 are constituted of an outer concavo-convex pattern 101, intermediate concavo-convex patterns 103 and an inner concavo-convex pattern 102. The outer concavo-convex pattern 101 and the inner concavo-convex pattern 102 are formed in a frame shape respectively along the outside and inside of a pattern of the sealing member 50a in the peripheral region of the array substrate 10d. Here, the outer concavo-convex pattern 101 and the inner concavo-convex pattern 102 are formed in the peripheral region excluding a liquid crystal injection hole 105. Moreover, between the outer concavo-convex pattern 101 and the inner concavo-convex pattern 102 on the array substrate 10d, the intermediate concavo-convex patterns 103 of approximately the same shape as that of the outer concavo-convex pattern 101 and inner concavo-convex pattern 102 are formed similarly in the peripheral region excluding the liquid crystal injection hole 105.

[0065] These concavo-convex patterns 100 are made of a silica film or a silicon nitride film, which is strong as a coating film. Moreover, a color mosaic filter and a common electrode are provided on the color filter substrate 20d, and an alignment film 40a is formed on them. Then, an alignment treatment is performed on the alignment films 40 and 40a which are formed respectively on the array substrate 10d and the color filter substrate 20d. Thereafter, the alignment films 40 and 40a are caused to face to each other to thereby arrange the array substrate 10d and the color filter substrate 20d opposed to each other. The array substrate 10d and the color filter substrate 20d are bonded with a predetermined gap apart from each other by use of the sealing member 50a which has been applied in a frame shape. Moreover, liquid crystals are injected between the array substrate 10d and the color filter substrate 20d from the liquid crystal injection hole 105, and the liquid crystals are sealed by a sealing member.

[0066] The second related art proposes that, by forming such concavo-convex patterns 100 in the peripheral region of the array substrate 10d, to which the sealing member 50a

is applied, the sealing member 50a is prevented from spreading out. With the outer concavo-convex pattern 101 and the inner concavo-convex pattern 102, a range for the sealing member 50a to spread out can be controlled, and a sealing width can be set to a predetermined width. In addition, as for the outer concavo-convex pattern 101, the inner concavo-convex pattern 102 and the intermediate concavo-convex patterns 103, the width and the height thereof are respectively set to 1 μm . The space between the inner concavo-convex pattern 102 and the outer concavo-convex pattern 101 is set to 0.55 mm. Moreover, the intermediate concavo-convex patterns 103 and the sealing member 50a together serve as a spacer for supporting the pair of substrates 10d and 20d.

[0067] Although the sealing member to be applied varies depending on positions on the substrate, the seal width of the sealing member can be set within a predetermined width by forming the inner concavo-convex pattern and the outer concavo-convex pattern, even if the array substrate 10d and the color filter substrate 20d are press-bonded with the sealing member 50a interposed in between in a seal adhesion process.

[0068] That is, the second related art describes that in the LCD device in which the electrodes and the alignment films are formed, the inner concavo-convex pattern 102 and the outer concavo-convex pattern 101 are formed as to enclose the sealing member 50a, and that the inner concavo-convex pattern 102 is formed as to enclose the display region 90a formed on one substrate of the pair of substrates. In the second related art, the concavo-convex patterns 101 and 102 are provided for preventing the sealing member 50 from flowing out, and it may appear that this concavo-convex pattern 102 exists between the alignment films 40 and 40a and the sealing member 50. However, because these concavo-convex patterns 101 and 102 act against the sealing member 50 and are for preventing the sealing member 50 from flowing out, they are formed after the alignment films 40 and 40a have been formed, and the alignment films 40 and 40a are not taken into consideration. Therefore, forming the alignment films in a uniform film thickness or doing the like is not taken into consideration.

[0069] Next, embodiments of the invention will be described in detail with reference to the accompanying drawings. Referring to FIG. 1, an LCD device 1 includes an array substrate 10 as a first substrate, a color filter substrate 20 as a second substrate, a sealing member 50 joining the first substrate and second substrates, and a liquid crystal layer 30 interposed between the first and second substrates. Alignment films 40 and 40a are provided on the surfaces of the respective substrates, the surfaces being in contact with the liquid crystal layer 30.

[0070] The embodiments are characterized by forming, between the sealing member 50 and the display region on each of the substrates, a print position control pattern 60 made of a member capable of repelling an alignment film material which forms the alignment films 40 and 40a.

[0071] In addition, the array substrate 10 is provided with, on the substrate 11, TFTs 12 as switching elements, and pixel electrodes as well as other electrodes to serve as the display region, the pixel electrodes and the other electrodes being connected to the switching elements. The array substrate 10 is provided with the alignment film 40 on top of the

substrate **11** on which these elements are provided. The color filter substrate **20** is provided with a black matrix **70** and a color filter **80** on the substrate **21**. The color filter substrate **20** is provided with the alignment film **40a** on the black matrix **70** and the color filter **80**. Moreover, the alignment films **40** and **40a** are deposited by discharging the alignment material from above the respective substrates by the non-contact printing method and by baking them.

[0072] A method of manufacturing the LCD device as above is described. First, as shown in Step S1 of FIG. 2, elements and the pixel electrodes are formed on the array substrate **10**, followed by forming a black matrix layer and a color filter layer on the color filter substrate **20**. At the same time, the print position control patterns **60** for controlling the spreading as liquid of the droplets are formed between the sealing member **50** and the display region on the array substrate **10** and on the color filter substrate **20**, the droplets being made of the alignment film material and being discharged from above the respective substrates.

[0073] Each of the print position control patterns **60** is formed as a region or a structure which can easily repel the alignment film material. The region which can easily repel the alignment film material is generally a region to which a low surface energy treatment was performed, as in a case of a first embodiment described below. Moreover, the structure which can easily repel the alignment film material is a structure in which at least concave structures or convex structures are formed, as in a case of second and third embodiments described below.

[0074] Next, as shown in Step S2, the alignment films are formed on the respective substrates **10** and **20** by the alignment film printing method of the non-contact type. Subsequently, as shown in Step S3, a rubbing treatment is performed to the alignment films by a well-known method. The processes after this rubbing treatment may be based on conventionally used techniques. That is, the sealing member **50** is formed in Step S4, the respective substrates **10** and **20** are bonded in Step S5, and liquid crystals are injected through a liquid crystal injection hole to form the liquid crystal layer **30** in Step 6. Moreover, the injection hole is sealed to form a liquid crystal panel in Step S7, and an isotropic treatment is performed to the liquid crystal panel to complete the liquid crystal panel in Step S8.

[0075] In the embodiments, the print position control patterns **60** for controlling the spreading as liquid of the alignment films **40** and **40a** are formed between the sealing member **50** and each of the display regions on the respective substrates **10** and **20**. Then, the alignment film material is printed in the display region, i.e., inside the print position control patterns **60**, by the printing method of the non-contact type. This printed alignment film material spreads as liquid in the direction toward the periphery of the display region while leveling off by self-weight, and eventually, the spreading as liquid is controlled by the print position control patterns **60**. Because it is possible to arbitrarily control the regions, in which the alignment films are formed, with the respective print position control patterns **60**, it is possible to form alignment films having small variations in the film thickness between the center of the display region and the edge portion of the display region, by printing the alignment film material of the amount corresponding to a product of the surface area and the film thickness.

[0076] Moreover, because it is possible to control the spreading as liquid of the alignment film material with the configuration of the embodiments, the patterning of the edge portion of the alignment films is significantly facilitated. Moreover, it is possible to reduce the distance between the sealing member for bonding the opposed substrates and the display region, and to manufacture an LCD device consisting of a narrow frame. Furthermore, as a result that the patterning accuracy of the alignment films is improved, there is no display irregularity, and it is possible to improve the display quality of the LCD device.

(First Embodiment)

[0077] In the first embodiment of the invention, each of print position control patterns **60** is formed as a region which can easily repel the alignment film material, i.e., a region to which a low surface energy treatment is performed and which has high water repellency to the alignment film material.

[0078] Referring to FIG. 4, an alignment film printing apparatus for printing the alignment films of this embodiment is described. An alignment film printing apparatus **410** includes a tank **413** for storing an alignment film material **411**, a print head **414** for discharging the alignment film material **411** onto a substrate **11**, and a stage **416** on which the substrate **11** is placed. The print head **414** is filled with the alignment film material **411** through a supply tube from the tank **413** of the alignment film material **411**. In the print head **414**, nozzles for discharging the alignment film material **411** at equal intervals are arranged, and each of the nozzles has a mechanism for arbitrarily discharging the alignment film material in response to a signal from a control unit (not shown).

[0079] In the printing process of the alignment films, as shown in FIG. 3A, first, TFTs and the print position control pattern **60** are formed on the array substrate. A color filter **80**, a black matrix **70**, and the print position control pattern **60** to which the low surface energy treatment has been performed are formed on the color filter substrate. In a region to which the low surface energy treatment has been performed, the surface energy becomes low, causing liquid thereon (i.e., the alignment film material in the invention) to be repelled easily. For example, a fluorine coating is a coating which reduces the surface energy. As the method of forming the print position control pattern **60** by means of this low surface energy treatment, for example, one may consider a method of selectively applying a water-repellent treatment material to the surface of the substrate, and evaporating the solvent, thereby fixing the water-repellent treatment material to the surface of the substrate. It is preferable that the water-repellent treatment material be a material such as a solvent obtained by dissolving general fluorine resin, hydrocarbon resin or silicone resin into an alcoholic solvent, which can easily repel the alignment material. Next, as shown in FIG. 3B, the print head **414** of the alignment film printing apparatus **410** scans the respective substrates **11** and **21** from a position above the substrates placed on the stage **416**, and discharges the droplets **41** of the alignment film material **411** onto the respective substrates **11** and **21** from the print head **414**, thereby performing the printing. As shown in FIG. 3C, the alignment film materials **411** printed on the respective substrates **11** and **21** spread by self-weight of the alignment film material, thereby leveling

off the printing irregularity of the alignment film material. Here, in the regions where the print position control patterns **60** have been formed, the spreading as liquid of the alignment film material is suppressed. Accordingly, as shown in FIG. 3C, it is possible to form an arbitrary pattern of the alignment film material. Thereafter, as shown in FIG. 3D, by baking the substrate to which the alignment film material has been printed, the alignment films **40** and **40a** can be formed.

[0080] Next, the appearance of the printed alignment film material, the arrangement of the nozzles **412** of the print head **414**, the appearance of the alignment film material **411** immediately after the printing, and the state where the alignment film material has been printed and has spread as liquid, and the like will be described. Referring to FIG. 5A, in the print head **414**, nozzles **422** for discharging the alignment film material at a selected interval (at a nozzle pitch **415**) are formed. FIG. 5B shows a state immediately after the print head **414** completed the printing, by scanning the substrate **11** from one edge to the other edge of the substrate **11** at a selected speed, and by subsequently scanning the substrate **11** after shifting the position of the head **414**.

[0081] As apparent from FIGS. 5A to 5C, the printed droplets **41** of the alignment film material are arranged on the substrate at intervals corresponding to the scanning speed and the nozzle pitch **415**. As shown in FIG. 5C, the droplets **41** of the alignment film material, which landed on the substrate **11**, spread as liquid instantaneously and overlap with each other to level off. Here, as for the droplets **41** of the alignment film material, which landed on the periphery of the display region **90**, regions **42** and **43** to spread as liquid are suppressed by the print position control pattern **60**, and the edge portion of the alignment film **40** is controlled.

[0082] Next, the change of states of the film thickness of the alignment film material printed to the entire surface of the substrate is described. As shown in FIG. 6A, the printed droplets **41** of the alignment film material are applied to the display region **90** on the substrate **11**. Here, the print position control pattern **60** is provided in the periphery of the display region **90** on the substrate **11**. As shown in FIG. 6B, the droplets **41** of the alignment film material spread as liquid in the direction toward the periphery of the display region **90** while leveling off by self-weight, eventually spread as liquid to the print position control pattern **60**, and is controlled by the print position control pattern **60** as shown in FIG. 6C. Accordingly, as shown in FIG. 6D, it is possible to narrow the region **44** in which the film thickness of the alignment film **40** is small.

[0083] Next, the print head in the alignment film printing apparatus **410** is described, the print head performing the non-contact printing of the alignment film. In a case where an ink-jet method is used as a print-head technique for performing this non-contact printing of the alignment film, an ink-jet head **420** is provided with a number of fine nozzles **422** in one surface of the head using piezoelectric elements **421**, as shown in FIG. 7. A diameter of each of the nozzles **422** is about 100 μm . The piezoelectric elements **421** which vibrate with a voltage are respectively arranged in the nozzles **422**. As shown in FIG. 7B, when a voltage is applied to the piezoelectric elements **421**, the piezoelectric elements **421** deform, and the alignment film material **411** which is the

liquid for the printing is pressed, thereby the droplets **41** of the alignment film material are discharged as shown in FIG. 7C.

[0084] In this embodiment, because it is possible to arbitrarily control the area in which the alignment film **40** is formed by this print position control pattern **60**, it is possible to form an alignment film having small variations of the film thickness between the center of the display region and the edge portion of the display region by printing the alignment film material of the amount corresponding to a product of the surface area and the film thickness. In this way, in this embodiment, it is possible to control the edge portion of the periphery of the alignment film, and to control the uniformity of the film thickness, in the case where the alignment film is formed on the substrate by the non-contact method of printing the alignment film. Moreover, as shown in FIG. 6D, it is possible to narrow the region **44**, in which the film thickness of the alignment film **40** is small, between the display region **90** and the print position control pattern **60**. This makes it possible to realize the LCD device with a narrow frame.

(Second Embodiment)

[0085] This embodiment is characterized by forming, between a sealing member **50** and each of display regions on the respective substrates, the print position control patterns consisting of a concave structures or convex structures **61** capable of repelling the alignment film material which forms alignment films **40** and **40a**.

[0086] This LCD device **1a** includes an array substrate **10a** as a first substrate, a color filter substrate **20a** as a second substrate, the sealing member **50** joining the first and second substrates, and a liquid crystal layer **30** interposed between the first and second substrates. The alignment films **40** and **40a** are provided on the surfaces of the respective substrates, the surfaces being in contact with the liquid crystal layer **30**.

[0087] As for the print position control patterns of this embodiment, at least the concave structures or the convex structures **61** are formed by a photolithographic method. Moreover, the alignment films **40** and **40a** are deposited by discharging the alignment material from above the respective substrates by the non-contact printing method and by baking them.

[0088] The manufacturing flow of this embodiment is described. As shown in FIG. 9A, first, a wiring layer **13**, switching elements **12** and pixel electrodes are formed on the array substrate. As for the switching elements, although TFTs are preferably used, other switching elements such as MIM (Metal Insulator Metal) element may be used. The wiring layer **13** includes gate electrodes and source electrodes in the case where TFTs are used as the switching elements **12**. Moreover, in order to form the gate electrodes and data electrodes, a metal film is deposited on the substrate **11** as shown in FIG. 9A.

[0089] Next, in order to form the concave structures or the convex structures of the print position control patterns **61** between the region to which the seal are applied and the wiring pattern region together with the display region, as shown in FIG. 9B, photoresist is applied to the substrate, and is exposed and developed into an arbitrary photoresist pattern **14**. Thereafter, as shown in FIG. 9C, by etching with

the use of this photoresist pattern **14** as a mask, print position control patterns including the concave structures or convex structures **61** are formed simultaneously with the wiring patterns. Here, as for the material for forming the print position control patterns, it is needless to say that a similar effect can be obtained not only with the metal film, but also with a conductive film, an insulating film and an organic film. Moreover, because it is possible to form the print position control patterns simultaneously with the wiring patterns, contact holes and the like, it is possible to perform the formation in the same way as the conventional process without adding a new manufacturing process.

[0090] Subsequently, as shown in FIG. 9D, the alignment film material is printed to the first substrate by using the non-contact alignment film printing method. The printed alignment film material starts to spread as liquid in portions other than the print position control patterns **61** immediately after the printing. Thereafter, drying and baking are performed to form the alignment films **40** and **40a** of a desired film thickness. Here, the purpose of the print position control patterns is to form the concave structures or the convex structures **61**, and therefore the etching amount may not be equivalent to that for forming the wirings.

[0091] Next, a method of manufacturing the second substrate **20a** including the color filter is described. As shown in FIG. 9A, a black matrix layer **71** formed between pixels is formed of a resin and a metal layer by a well-known method. As in the case of the first substrate **10a**, as shown in FIG. 9B, photoresist is applied to the formed black matrix layer **71**, and is exposed and developed into the arbitrary photoresist pattern **14**. On the print position control pattern **61**, a pattern is formed so that fine concavo-convex structures are formed. Thereafter, as shown in FIG. 9C, by etching with the use of this photoresist pattern **14** as a mask, the black matrix layer **71** and a print position control pattern constituting of the fine concavo-convex structures are formed. Thereafter, on the second substrate **21**, a color filter layer made of dye or pigment is formed by a well-known method, thereby forming ITO electrodes. Here, as for the material for forming the fine concave structures or fine convex structures, it is needless to say that a similar effect is obtained not only with the material used for the black matrix layer **71**, but also with the color filter material and the other materials.

[0092] Subsequently, as shown in FIG. 9D, the alignment film material is printed to the second substrate **20a** by using the non-contact alignment film printing method. The printed alignment film material starts to spread as liquid in portions other than the print position control pattern **61** immediately after the printing. Thereafter, drying and baking are performed to form the alignment film **40a** of a desired film thickness. Here, the first and second substrates may be a type used for a liquid crystal mode of a vertical electric field control system in which a voltage is applied between the substrates, or a type used for a liquid crystal mode of a horizontal electric field control system in which a voltage is applied in the direction parallel to the substrates.

[0093] As for the first and second substrates formed in this manner, an alignment treatment such as a rubbing treatment or the like is performed to the alignment films **40** and **40a**, and then the substrates are bonded to form an LCD device.

As for the manufacturing method after the alignment treatment, a well-known technique is used, so the description thereof is omitted.

[0094] Next, the action principle of the print position control patterns including the fine concave structures or fine convex structures **61** is described. FIGS. 10A is a side view showing a state where the droplet **41** of the alignment film material is dripped onto the substrate **11**, on which the fine concave structures or the fine convex structures are formed. FIG. 10B, is a side view showing a state where the droplet **41** of the alignment film material is dripped onto a flat substrate. Referring to FIG. 10A, on the substrate **11**, there are formed the concave structures or convex structures **61** smaller than the droplet **41** of the alignment film material which landed thereon. In order to obtain the effect of the print position control patterns **61**, the width of a depression of each of the concave portions needs to be reduced. If the width of the depression of each of the concave portions is reduced, air interfaces **419** are formed between the substrate and the droplet **41** which has been printed to the substrate, and the droplet **41** can easily be repelled, thereby making it possible to control the spreading as liquid of the droplet **41**.

[0095] The diameter of the droplet **41** discharged from the print head is approximately from 50 μm to 100 μm . The diameter of each of the droplets **41** at the time when the droplets **41** which landed on the substrate spread as liquid is approximately 1 mm. The nozzle pitch of the print head is set to approximately from 50 μm to 100 μm . In order to form air interfaces between the substrate and the droplet **41** which has been discharged to the substrate, the width of the depression of each of the concave portions needs to be 50 μm or less. Moreover, in order to enlarge the surface area of the air interfaces which the droplet comes in contact with, the region in which the concave portions are formed needs to be enlarged. Particularly, a significant effect of the print position control was obtained by setting the area ratio of the concave portions to each of the print position control patterns **61** to $\frac{1}{2}$ or more.

[0096] Furthermore, with regard to the depth of the depression of the print position control patterns **61** of the concave structures or convex structures, the inventor conducted verification by carrying out a printing experiment. As a result, data shown in Table 1 as follows were obtained. This table relates to the depression depth of the concave portions or convex portions and to the controllability of the edge portion of the alignment film concerning the second embodiment.

TABLE 1

Depression depth of the concave portions or convex portions (nm)	Controllability of the edge portion of the alignment film
0	X
50	Δ
100	\bigcirc
150	\bigcirc
200	\bigcirc

[0097] Results in Table 1 confirmed that, in the case where the alignment film material is printed by using the non-contact alignment film printing method, the controllability of the edge portion of the alignment film was improved by setting the depression depth of the concave structures or

convex structures to 50 nm or more, and there was a significant improvement in a case of setting thereof to 100 nm. In order to improve the print position controllability of the alignment film material, the depth of the depression of the concave structures or convex structures needs to be 50 nm or more. It is preferably 100 nm or more.

[0098] Here, the fine concave structures or fine convex structures formed in the print position control pattern **61** may be a print position control pattern **61a** of concave structures or convex structures formed in a matrix as shown in FIGS. 11A and 11B. Moreover, as shown in FIGS. 12A and 12B, a print position control pattern **61b** of concave structures or convex structures formed in a delta arrangement or a staggered arrangement may be used. Moreover, a print position control pattern arranged at random may be used. Moreover, the shape of the concave structures or convex structures to be formed in the print position control pattern may be a square, a circle or a polygon such as a hexagon, as shown in FIGS. 13A to 13C.

[0099] According to this embodiment, it is possible to arbitrarily control the area, in which the alignment films **40** and **40a** are formed, by the print position control patterns **60** represented by the concave structures or convex structures **61**. Therefore, it is possible to form alignment films having small variations in the film thickness between the center of the display region and the edge portion of the display region, by printing the alignment film material of the amount corresponding to a product of the surface area and the film thickness. In this way, this embodiment makes it possible to control the edge portions of the respective alignment films and to control the uniformity of the film thickness, in the case of forming the alignment films by the non-contact method of printing alignment films to the respective substrates. Moreover, it is possible to form the concave structures or convex structures **61** simultaneously with the forming of the elements on the substrate, such as wiring patterns. This makes it possible to form alignment films having small variations in the film thickness between the center of the display region and the edge portion of the display region without adding a new manufacturing process, and it is possible to control the edge portions of the respective alignment films.

(Third Embodiment)

[0100] Next, a third embodiment as a specific embodiment of the invention is described with reference to FIG. 14. This embodiment is characterized by forming, between a sealing member **50** and each of display regions on the respective substrates, pillar-shaped bodies **62** and **62a** each made of a pillar-shaped member as print position control patterns on the respective substrates, the print position control patterns being capable of repelling the alignment film material which forms alignment films **40** and **40a**. The pillar-shaped bodies **62** and **62a** are provided opposed to each other as to support the first and second substrates at a selected space. The pillar-shaped bodies **62** and **62a** control the range which the alignment films spread as liquid by enclosing the peripheries of the alignment films **40** and **40a**, and thereby making it possible to control the positions where the alignment films **40** and **40a** are formed.

[0101] An LCD device **1b** of this embodiment includes an array substrate **10b** as a first substrate, a color filter substrate **20b** as a second substrate, the sealing member **50** joining the

first and second substrates, a liquid crystal layer **30** interposed between the first and second substrates, and the pillar-shaped bodies **62** and **62a**. The alignment films **40** and **40a** are provided on the surfaces of the respective substrates, the surfaces being in contact with the liquid crystal layer **30**.

[0102] These pillar-shaped bodies **62** and **62a** are formed of resin such as photoresist or the like by a photolithographic method. For example, the pillar-shaped body **62a** can be also formed by depositing the color filter layer **80**. Moreover, the pillar-shaped body **62a** can be also formed by patterning resin or the like. It should be noted that, in the case of the array substrate **10b**, it is preferable to pattern resin or the like.

[0103] In addition, this embodiment can be considered as the one made by enlarging the convex structures for controlling the spreading as liquid shown in FIGS. 11A and 12A, and by causing the enlarged convex portions to also serve as the pillars supporting the respective substrates. As for the arrangement of the pillar-shaped bodies, the pillar-shaped bodies need to be formed as to enclose the alignment films **40** and **40a** when viewed from the direction normal to the first substrate (or the second substrate). Moreover, because the sealing member **50** is also arranged further outside these pillar-shaped bodies, these pillar-shaped bodies enclose the alignment films **40** and **40a** inside the sealing member **50**, as in the case of the sealing member.

[0104] According to this embodiment, it is possible to arbitrarily control the area, in which the alignment film **40** can be formed, by the print position control pattern **60** represented by the pillar-shaped body **62**. Moreover, it is possible to arbitrarily control the area, in which the alignment film **40a** can be formed, by the print position control pattern **60** represented by the pillar-shaped body **62a**. This makes it possible to form the alignment films having small variations in the film thickness between the center of the display region and the edge portion of the display region, by printing the alignment film material of the amount corresponding to a product of the surface area and the film thickness. In this way, this embodiment makes it possible to control the edge portions of the respective alignment films and to control the uniformity of the film thickness, in the case of forming the alignment films by the non-contact method of printing the alignment films to the substrates. Because the pillar-shaped bodies **62** and **62a** are provided as opposed to each other, they can support the first substrate **10a** and the second substrate **20b** with a selected space, contributing to the maintenance of the cell gap.

(Fourth Embodiment)

[0105] Next, a fourth embodiment as a specific embodiment of the invention is described with reference to the drawings. In FIG. 7 of the first embodiment, as the non-contact alignment film printing method, the ink-jet method using the piezoelectric elements was described as the print head of the alignment film printing apparatus. On the other hand, a bubble jet (Registered Trademark) method can be used. A print head using this bubble jet method is described.

[0106] As shown in FIG. 15A, in a bubble jet print head **430** using this bubble jet method, a heater **431** is mounted in a tank filled with the alignment film material **411**. As shown in FIG. 15B, when electric power is supplied to the heater **431** to heat the alignment film material **411**, the alignment

film material 411 is expanded and air bubbles 432 are generated. Accordingly, the alignment film material 411 is pressed to discharge a droplet 41 of the alignment film material.

[0107] Although the preferred embodiments have been specifically described hereinabove, the invention is not limited to these embodiments and various modifications and applications are possible.

[0108] For example, as the non-contact alignment film printing method, a dispense method, which presses and discharges liquid by air can be also used. It should be noted that the method of printing alignment films can be applied to the non-contact methods of printing alignment films to the substrate, but is not limited to these methods. Moreover, according to the invention, a similar effect can be obtained not only by the non-contact printing method but also by a flexographic printing method.

[0109] Moreover, if the non-contact ink-jet method is used for forming the print position control patterns and printing the alignment films, the printing apparatus will not come in contact with the substrate, therefore there will be no transfer of foreign substances or the like from the device to the substrate, thereby bringing about an effect of decreasing the defects due to the foreign substances.

[0110] Moreover, in the embodiments described above, as shown in FIG. 2, the manufacturing method is as follows: the substrates 10 and 20 are bonded in Step S5, the liquid crystal layer 30 is formed by filling liquid crystal material between the substrates in Step S6, and the liquid crystal injection hole is sealed in Step S7. On the other hand, the invention can also be applied to a method of manufacturing an LCD device by a drip bonding method by dripping liquid crystals to one substrate, and subsequently bonding the both substrates by use of a sealing member, thereby producing a liquid crystal panel. The sequence of the method is known as one drop fill (ODF) process.

[0111] Moreover, the LCD devices of the first to third embodiments described above are the LCD devices in which the color filter is formed on the color filter substrate. On the other hand, the print position control patterns of the invention can also be applied to an LCD device of a color filter-on TFT type (COT type), for example, in which the color filter is also formed in the array substrate. The invention can be applied to an LCD device in which both substrates are bonded with a sealing member while interposing a liquid crystal layer between an array substrate, on which a color filter is formed, and an opposed substrate.

[0112] Although preferred embodiments of the invention has been described with reference to the drawings, it will be obvious to those skilled in the art that various changes or modifications may be made without departing from the true scope of the invention.

What is claimed is:

1. A liquid crystal display device comprising:
a pair of substrates each including a display region and a peripheral region around the display region;
a liquid crystal layer sandwiched between the substrates;

a sealing member provided between the peripheral regions of the pair of substrates, the sealing member sealing the liquid crystal layer;

alignment films provided between a surface of one of the pair of substrates and the liquid crystal layer, and between a surface of the other of the pair of substrates and the liquid crystal layer; and

print position control patterns provided between the sealing member and the display region, the print position control patterns each being made of a member for repelling a corresponding one of alignment film materials which form the alignment films.

2. The liquid crystal display device according to claim 1, wherein each of the print position control patterns is arranged between the display region and the sealing member.

3. The liquid crystal display device according to claim 1, wherein the print position control patterns respectively consist of regions each of which can easily repel the alignment film material.

4. The liquid crystal display device according to claim 3, wherein the regions which can easily repel the corresponding alignment film materials respectively consist of regions with water repellency to the alignment film materials.

5. The liquid crystal display device according to claim 1, wherein the print position control patterns respectively consist of structures which can easily repel the corresponding alignment film materials.

6. The liquid crystal display device according to claim 1, wherein the print position control patterns respectively consist of pillar-shaped bodies which are in contact with corresponding opposed substrates, and which support the substrates to keep a cell gap.

7. The liquid crystal display device according to claim 5, wherein each of the structures which can easily repel the corresponding alignment materials consists of a structure of a pattern repeating at least one of a concave structure and a convex structure.

8. The liquid crystal display device according to claim 7, wherein a width of each of depression portions of the repeated concave structures or the repeated convex structures of each of the print position control patterns is 50 μm or less.

9. The liquid crystal display device according to claim 8, wherein an area ratio of the depression portions of the repeated concave structures or the repeated convex structures of each of the print position control patterns to a region of the print position control pattern is $\frac{1}{2}$ or more.

10. The liquid crystal display device according to claim 8, wherein a depth of each of depressions of the repeated concave structures or the repeated convex structures of each of the print position control patterns is 50 nm or more.

11. The liquid crystal display device according to claim 7, wherein an area ratio of the depression portions of the repeated concave structures or the repeated convex structures of each of the print position control patterns to a region of the print position control pattern is $\frac{1}{2}$ or more.

12. The liquid crystal display device according to claim 11, wherein a depth of each of depressions of the repeated concave structures or the repeated convex structures of each of the print position control patterns is 50 nm or more.

13. The liquid crystal display device according to claim 7, wherein a depth of each of depressions of the repeated

concave structures or the repeated convex structures of each of the print position control patterns is 50 nm or more.

14. A method of manufacturing a liquid crystal display device including a pair of substrates each including a display region and a peripheral region around the display region; a liquid crystal layer sandwiched between the pair of substrates; and a sealing member provided between the peripheral regions of the pair of substrates, the sealing member sealing the liquid crystal layer, the method comprising the steps of:

forming print position control patterns each made of a member for repelling a corresponding one of alignment film materials which form alignment films, outside the respective display regions of the pair of substrates,

forming alignment films respectively on the display regions of the pair of substrates by a non-contact printing method, and

bonding the pair of substrates with the sealing member, and interposing the liquid crystal layer between the pair of substrates.

15. The method of manufacturing a liquid crystal display device according to claim 14, wherein the print position control patterns are respectively formed of regions each of which can easily repel the alignment film material.

16. The method of manufacturing a liquid crystal display device according to claim 15, wherein the regions which can easily repel the corresponding alignment film materials are respectively formed of regions with water repellency which suppresses the spreading of printing the alignment films.

17. The method of manufacturing a liquid crystal display device according to claim 14, wherein the print position control patterns are respectively formed of structures which can easily repel the corresponding alignment film materials.

18. The method of manufacturing a liquid crystal display device according to claim 17, wherein the structures which can easily repel the corresponding alignment film materials are respectively formed of regions including concave structures or convex structures which suppress the spreading of printing the alignment films.

19. The method of manufacturing a liquid crystal display device according to claim 18, wherein a width of each of depression portions of the concave structures or the convex structures of each of the print position control patterns is 50 μ m or less.

20. The method of manufacturing a liquid crystal display device according to claim 19, wherein an area ratio of the depression portions of the concave structures or the convex structures of each of the print position control patterns to a region of the print position control pattern is $\frac{1}{2}$ or more.

21. The method of manufacturing a liquid crystal display device according to claim 19, wherein a depth of each of

depressions of the concave structures or the convex structures of each of the print position control patterns is 50 nm or more.

22. The method of manufacturing a liquid crystal display device according to claim 18, wherein an area ratio of the depression portions of the concave structures or the convex structures of each of the print position control patterns to a region of the print position control pattern is $\frac{1}{2}$ or more.

23. The method of manufacturing a liquid crystal display device according to claim 22, wherein a depth of each of depressions of the concave structures or the convex structures of each of the print position control patterns is 50 nm or more.

24. The method of manufacturing a liquid crystal display device according to claim 18, wherein a depth of each of depressions of the concave structures or the convex structures of each of the print position control patterns is 50 nm or more.

25. The method of manufacturing a liquid crystal display device according to claim 18, wherein the regions including the concave structures or convex structures which suppress the spreading of printing the alignment films are formed by a photolithographic method.

26. The method of manufacturing a liquid crystal display device according to claim 17, wherein the print position control patterns are formed by a non-contact organic material printing method.

27. The method of manufacturing a liquid crystal display device according to claim 17, wherein the print position control patterns are respectively formed of pillar-shaped bodies which enclose the corresponding display regions, and which support the pair of substrates to keep a cell gap.

28. The method of manufacturing a liquid crystal display device according to claim 27, wherein the pillar-shaped bodies are formed by depositing color filter layers.

29. The method of manufacturing a liquid crystal display device according to claim 14, wherein the non-contact printing method is based on an ink-jet printing method.

30. The method of manufacturing a liquid crystal display device according to claim 29, wherein the ink-jet printing method causes droplets of the alignment film material to be discharged by controlling piezoelectric elements.

31. The method of manufacturing a liquid crystal display device according to claim 29, wherein the ink-jet printing method causes droplets of the alignment film material to be discharged by controlling heaters.

32. The method of manufacturing a liquid crystal display device according to claim 14, wherein the non-contact printing method is based on a dispense printing method.

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专利名称(译)	液晶显示装置及其制造方法		
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摘要(译)

本发明提供一种制造LCD器件的方法，其中通过在基板上印刷非接触取向膜的方法形成取向膜。在密封构件和每个显示区域之间提供打印控制图案。每个印刷控制图案由高度防水的区域以及精细凹陷结构，精细凸起结构和柱状体中的任何一种形成。印刷控制图案控制作为取向膜材料的液体的扩散，以使每个取向膜材料的膜厚均匀。

